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A dynamic addressing architecture for multi-electrode arrays towards
ultra-high-density DNA synthesis

2025-06-19

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STORAGE AND COMPUTING WITH DNA

Sorbonne University, Paris

From June 19th to June 21st 2025



IMEC IS A WORLD LEADING RESEARCH CENTER FOCUSING ON
SEMICONDUCTOR TECHNOLOGY, DESIGN AND APPLICATION

—
BRIDGING THE GAP BETWEEN ACADEMIA AND INDUSTRY.

IMEC WILL CONTINUE TO DRIVE
SEMICONDUCTOR FUNCTIONAL SCALING
IN THE COMING DECADE.

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IMEC THRIVES ON CONNECTING
THE SMART APPLICATION GRAND CHALLENGES
WITH ITS STRENGTH IN
ADVANCED SEMICONDUCTOR TECHNOLOGY
CREATING A SUSTAINABLE SOCIETY.

World-class infrastructure

Hyperspectral imaging lab & demo room

Integrated imagers lab

Smart sensor lab

ExaScience lab

RF & high-power lab

Photonics labs

Measurement & testing lab
GaN lab

300 mm cleanroom

- (High-NA) EUV, Attolab, advanced patterning
- State-of-the-art etch, implant, cleaning, metrology, deposition, ... equipment from leading-edge OEMs
- Ballroom type of cleanroom (7,200m², Class 1,000)
- 24/7 operational

Material and device
characterization labs

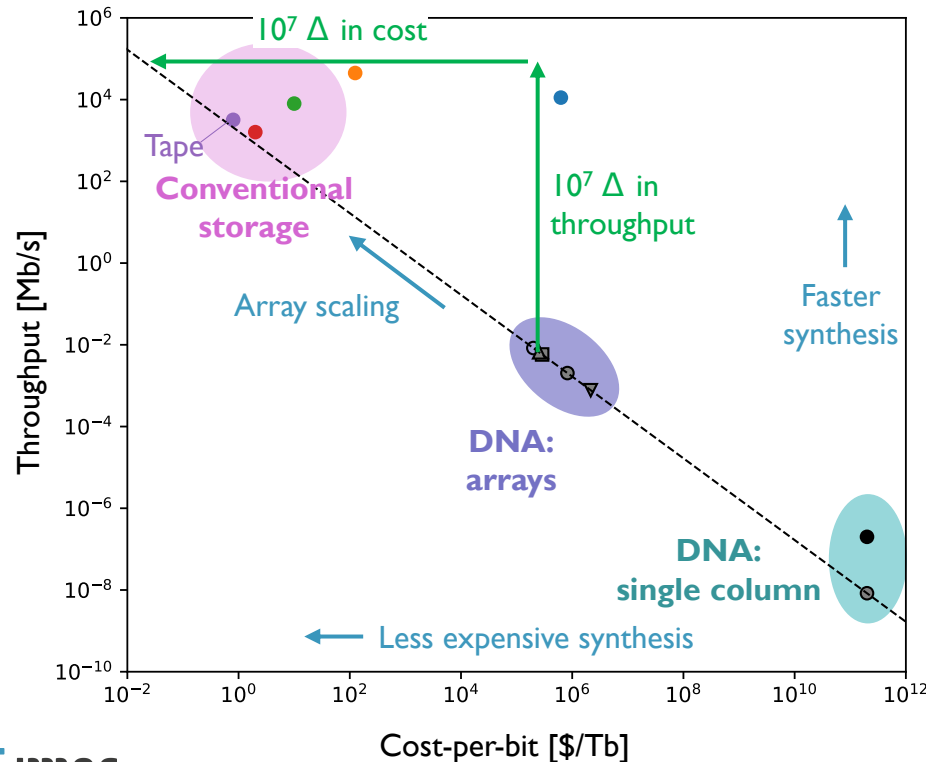
Bio labs

- Cell & tissue culture labs
- Optical labs
- Wet chemistry labs
- Clinical labs
- Pre-PCR lab
- Neuropixels lab

200 mm cleanroom

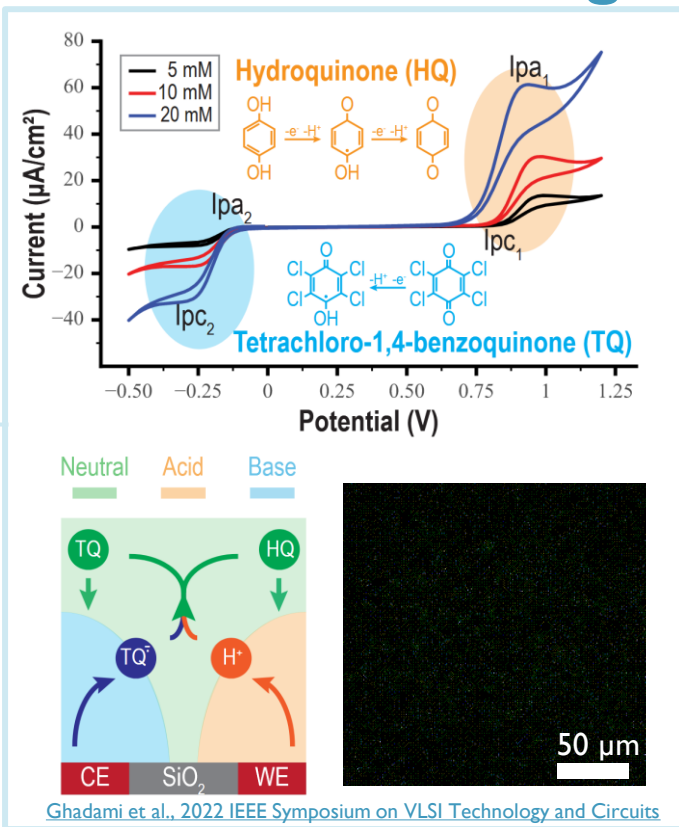
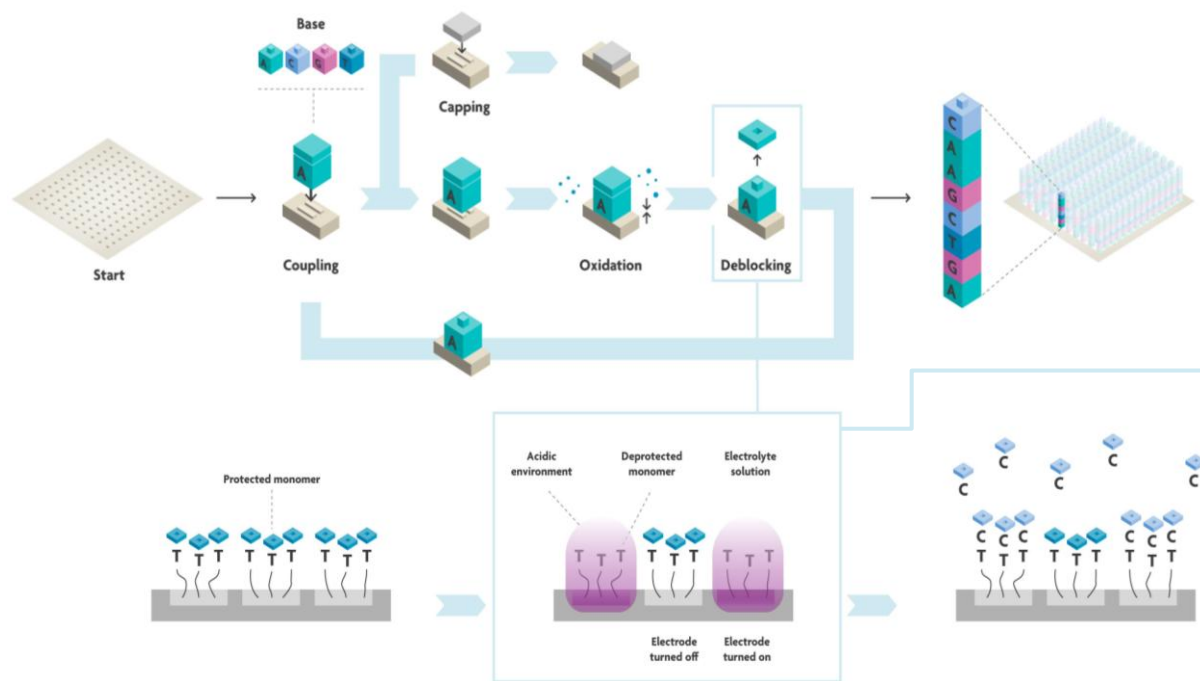
- Silicon pilot line for prototyping and low-volume manufacturing
- iSiPP200 and iSiPP50G photonics prototyping platform
- 200mm GaN-on-Si platform
- Quantum computing lab
- Materials & interface lab
- 5,200 m²

The **cost** and **throughput** gaps facing the “**write**” aspect of DNA-based data storage span **many orders of magnitude**



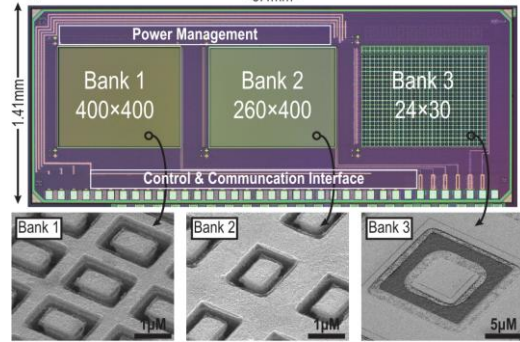
- Both **cost** and **throughput** require at least **1E7x improvement** to **surpass tape**, the current SoA
- Both can be tackled at the same time through **density scaling** of the synthesis sites
- However, for archival storage the **total cost-of-ownership (TCO)** is more relevant than the raw write-cost

DNA synthesis can be **multiplexed** on micro-electrode arrays using **localized quinone electrochemistry** to perform the **deblocking**



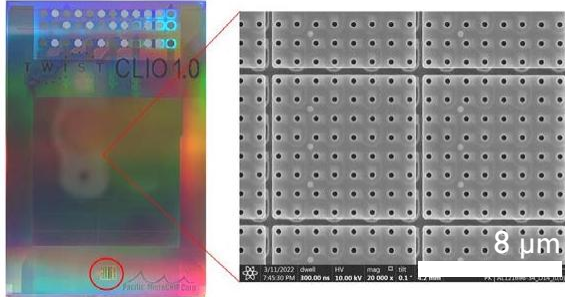
Underneath each electrode sits a CMOS-based **switch** that must be as **small** as possible while remaining **application-compatible**

HELIX: 160K sites on $\sim 0.7 \times 0.9 \text{ mm}^2$ ($1.8 \times 2.2 \mu\text{m}^2$)

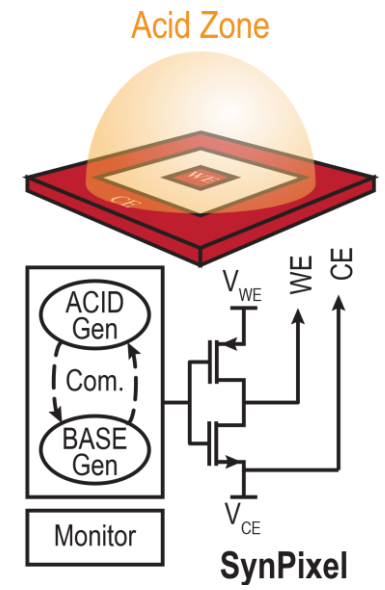
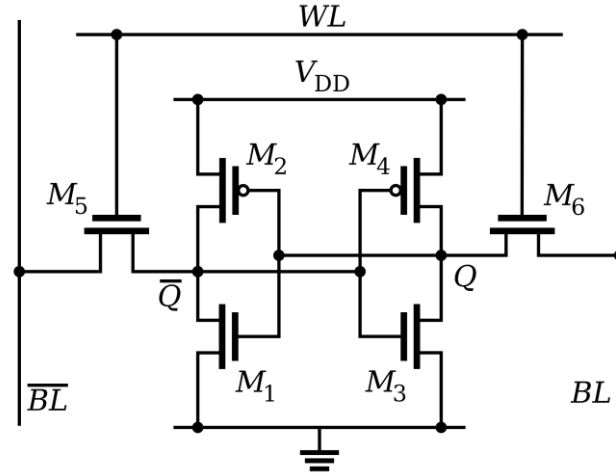


Ghadami et al., 2022 IEEE Symposium on VLSI Technology and Circuits

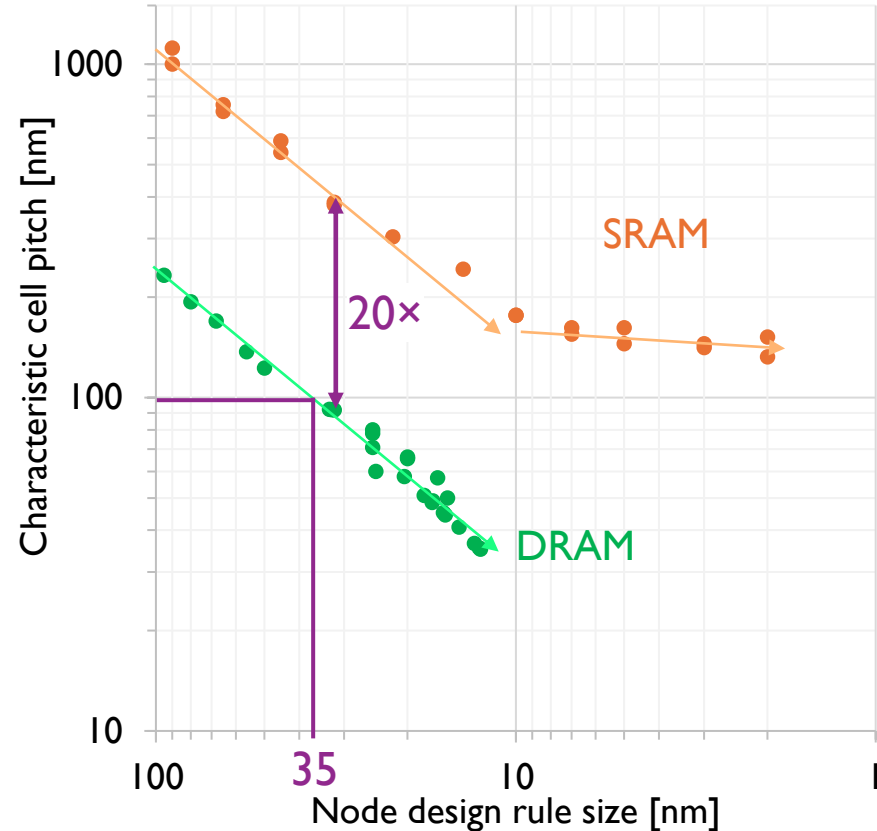
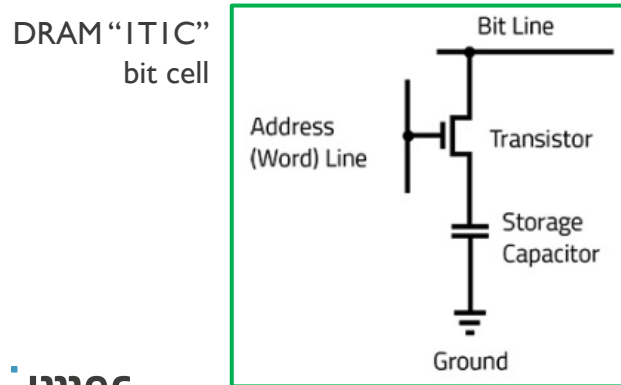
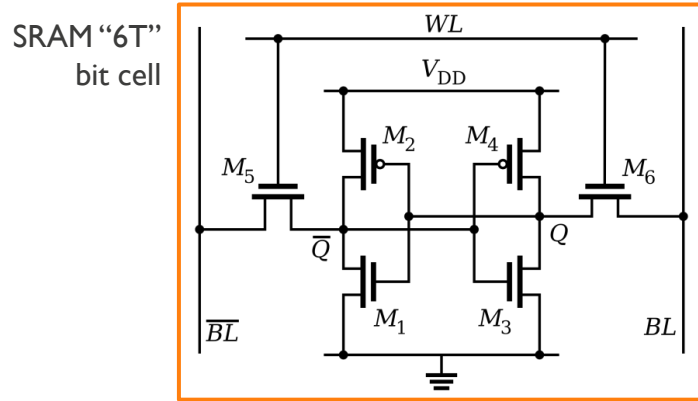
Twist: 128M sites on $\sim 20 \times 20 \text{ mm}^2$ ($1 \times 2 \mu\text{m}^2$)



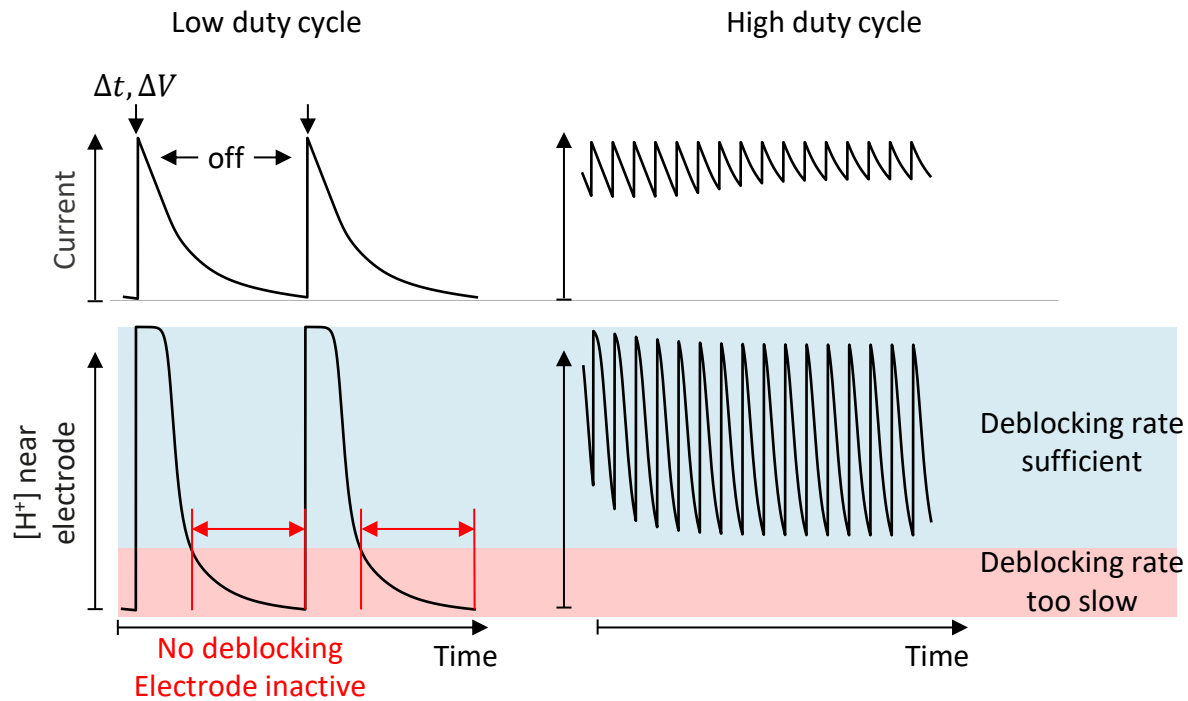
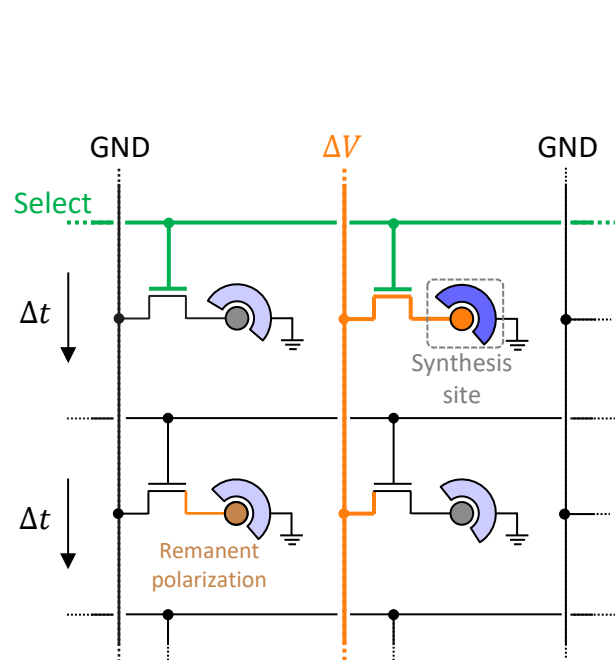
SRAM (6T): both a memory and switch



For a similar technology node, **dynamic** memories require **20× less area per bit cell** compared to **static** memories

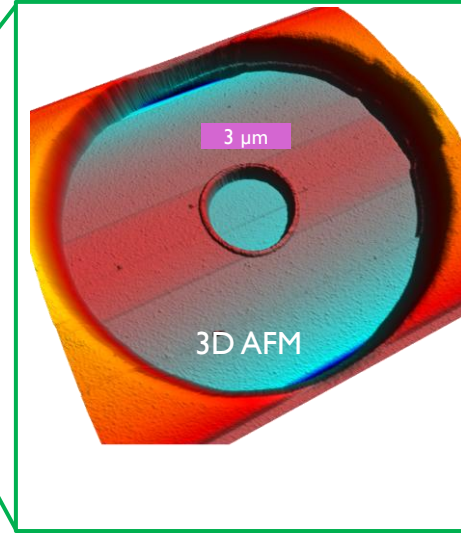
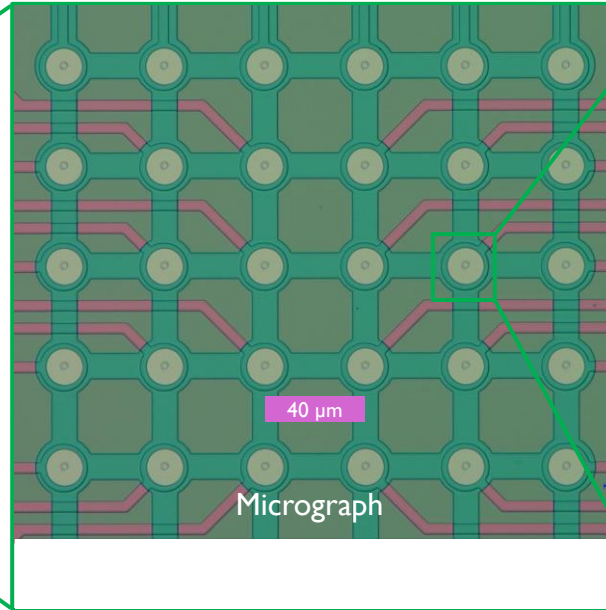
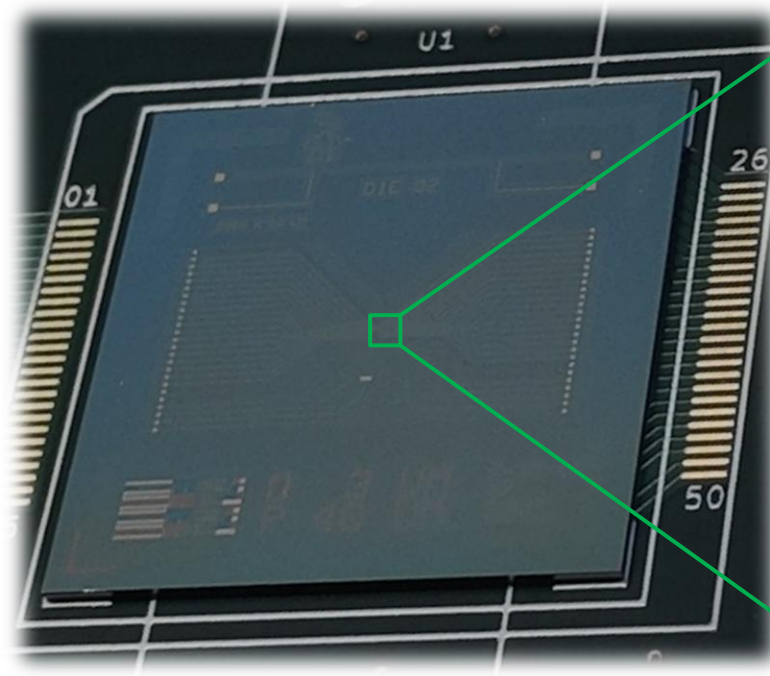


Dynamic addressing can drive electrochemical **deblocking**, but we must determine the **minimal duty cycle** that can sustain it



Our **experimental test device** consists of a micro-electrode array with 36 (6×6) externally driven platinum **ring-disk pairs**

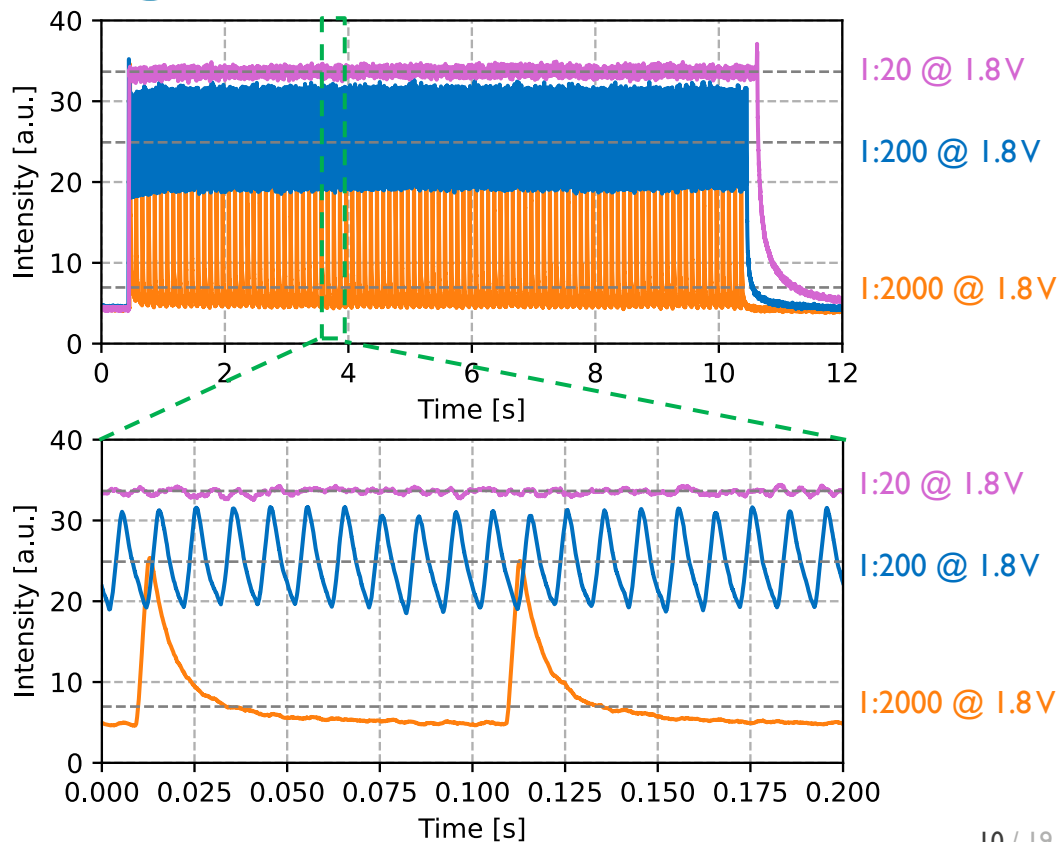
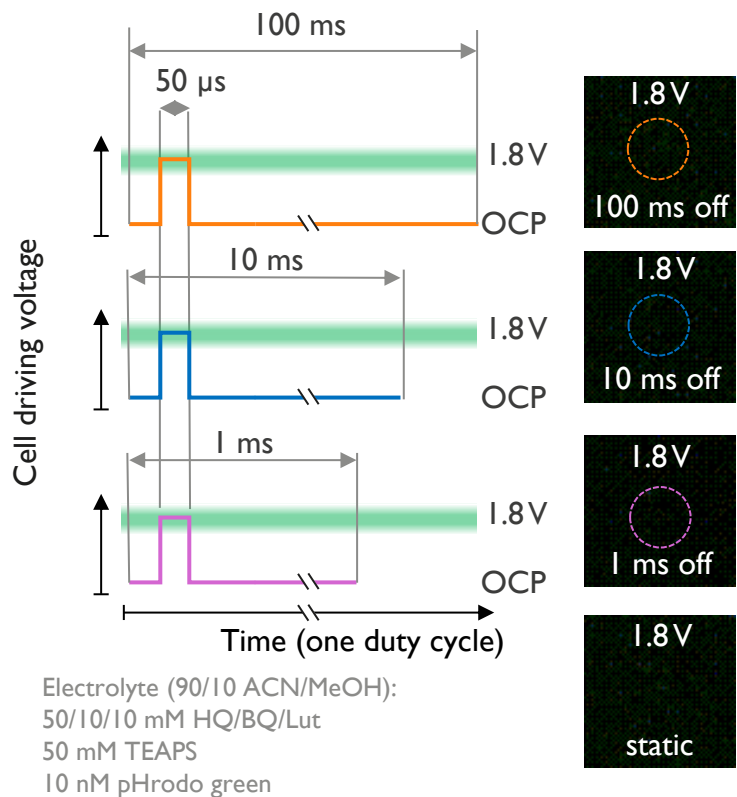
Disks: Individually addressed working electrodes
Rings: common counter electrodes



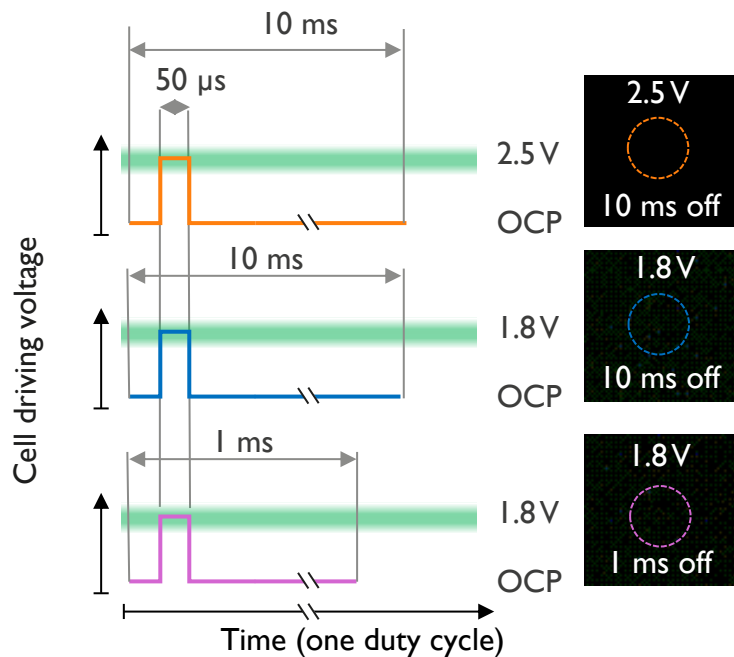
6x6 micro-electrode array
40 μm center-to-center pitch

$d_1 = 3 \mu\text{m}$ $h_1 = 200 \text{ nm}$
 $d_2 = 15 \mu\text{m}$ $h_2 = 200 \text{ nm}$

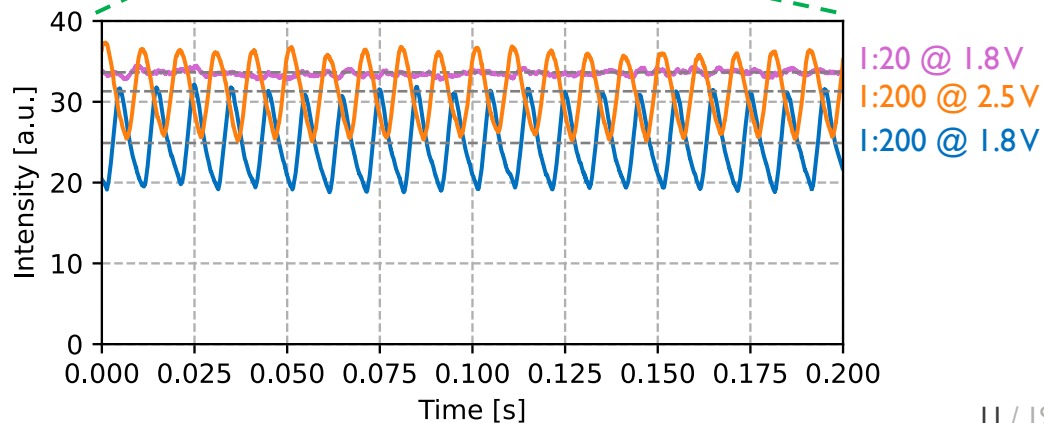
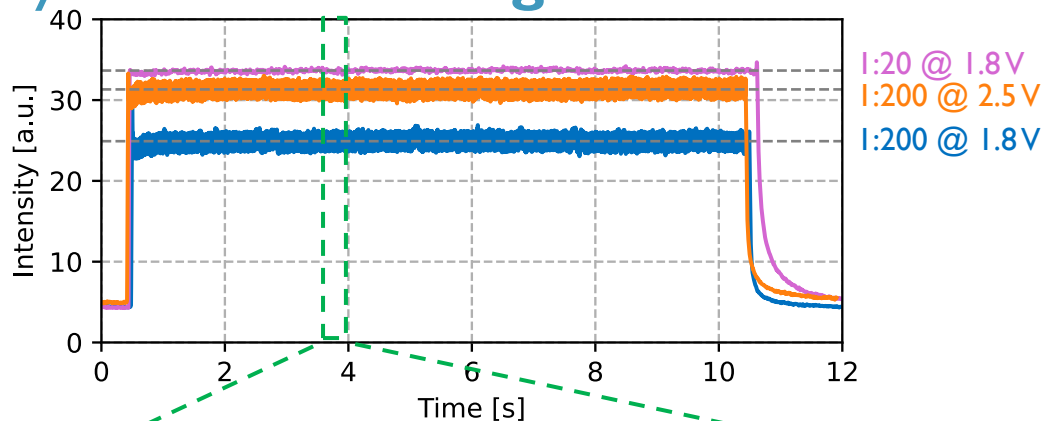
Experimentally, the **maximal off-time** is **1–5 ms** and largely determines the **efficiency of acid generation**



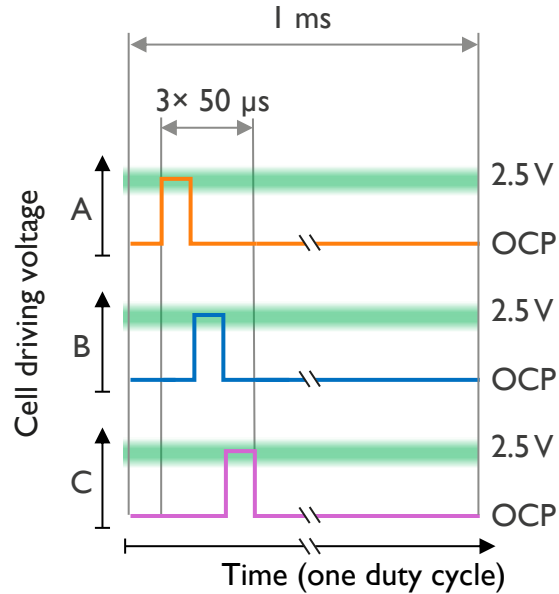
Modestly increasing the driving voltage from 1.8 to 2.5 V allows for increasing the off-time by an order of magnitude



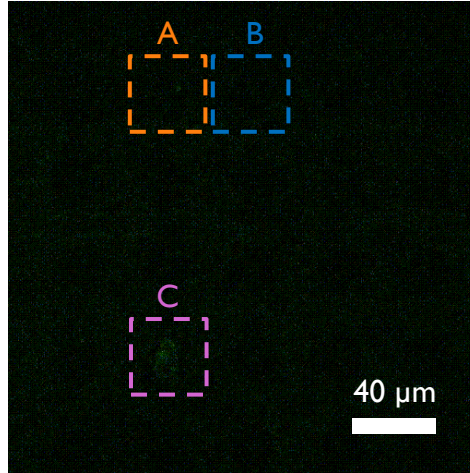
Electrolyte (90/10 ACN/MeOH):
50/10/10 mM HQ/BQ/Lut
50 mM TEAPS
10 nM pHrodo green



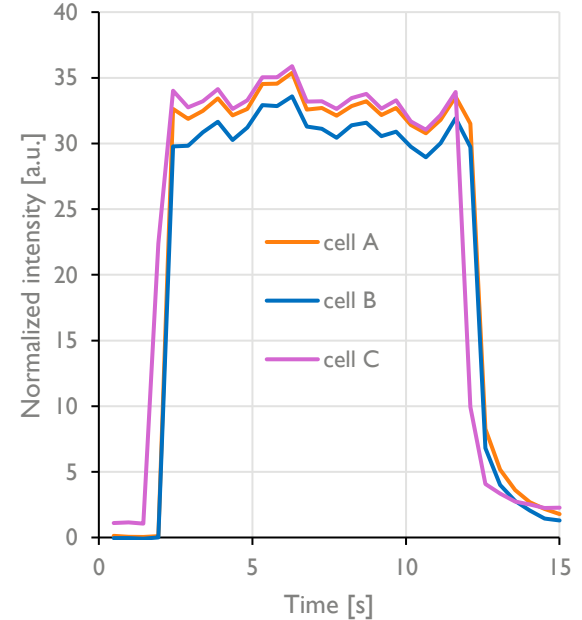
Multiple electrodes can be activated simultaneously by sequential dynamic addressing within a single duty cycle



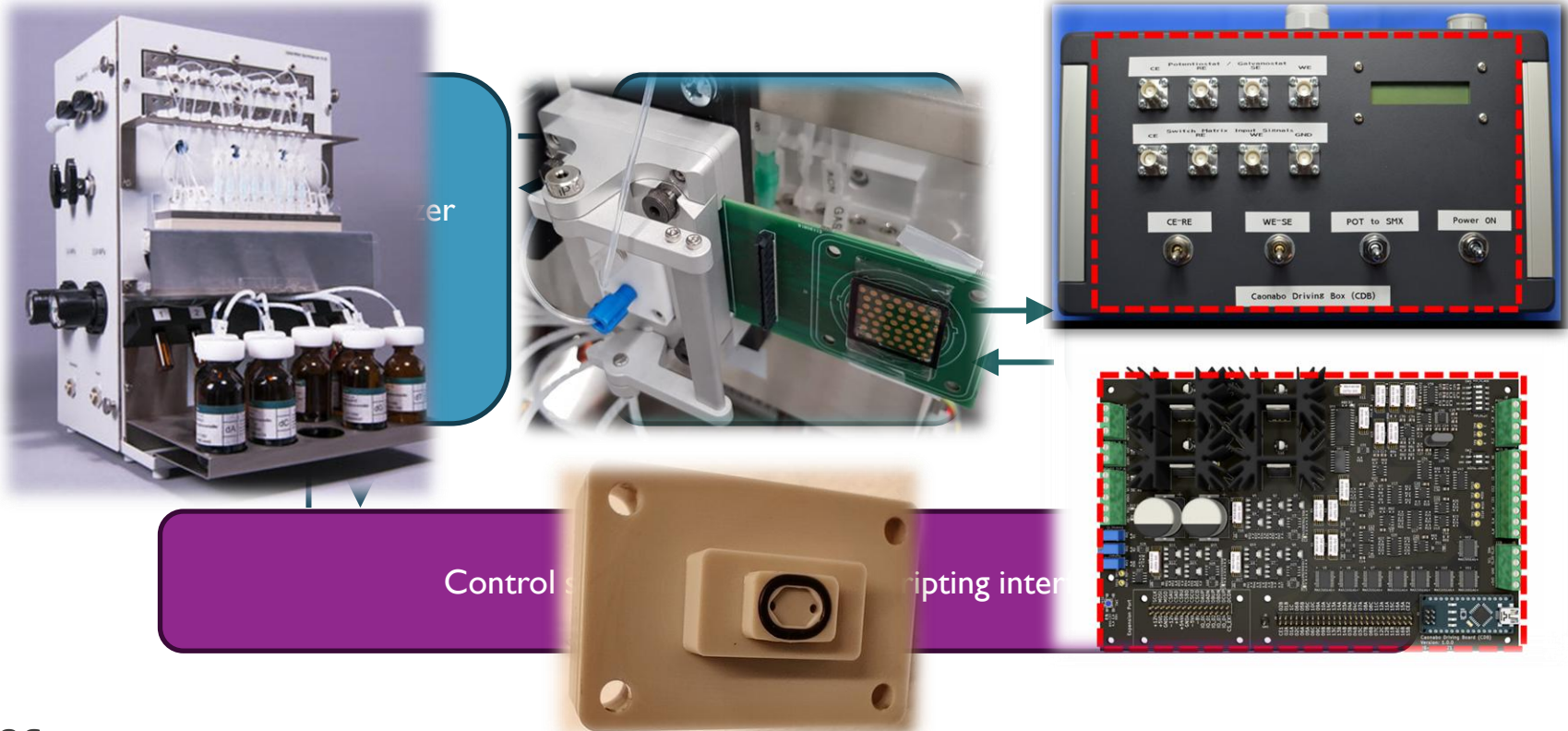
Addressing conditions:
50 μs on @ 2.5 V
1 ms off @ OCP



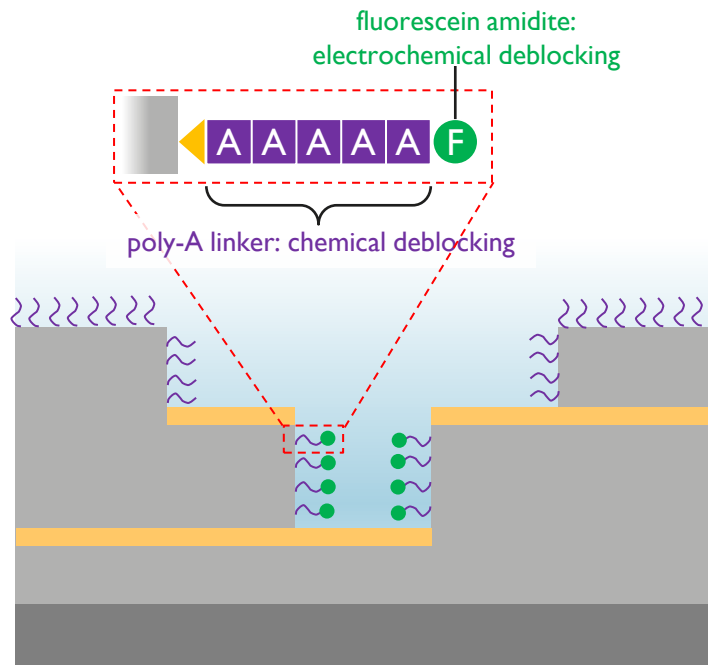
Electrolyte (90/10 ACN/MeOH):
50/10/10 mM HQ/BQ/Lut
50 mM TEAPS
10 nM pHrodo green



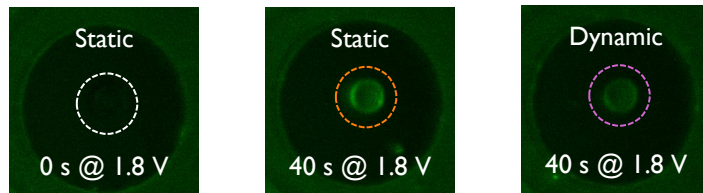
Our setup consists of a combination of **commercial** and **custom-build hardware**, controlled by **in-house developed software**



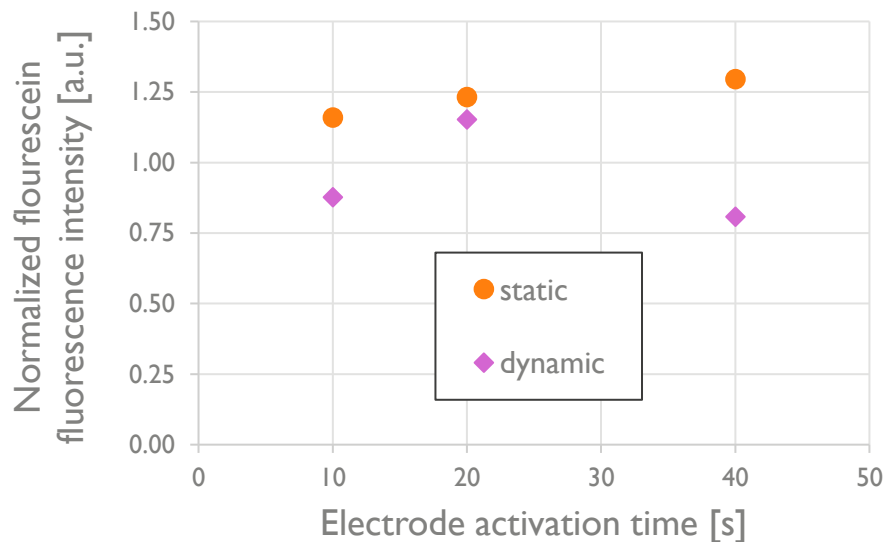
Dynamic and static addressing have a comparable electrochemical deblocking strength



Electrolyte (90/10 ACN/MeOH):
50/10/10 mM HQ/BQ/Lut
50 mM TEAPS

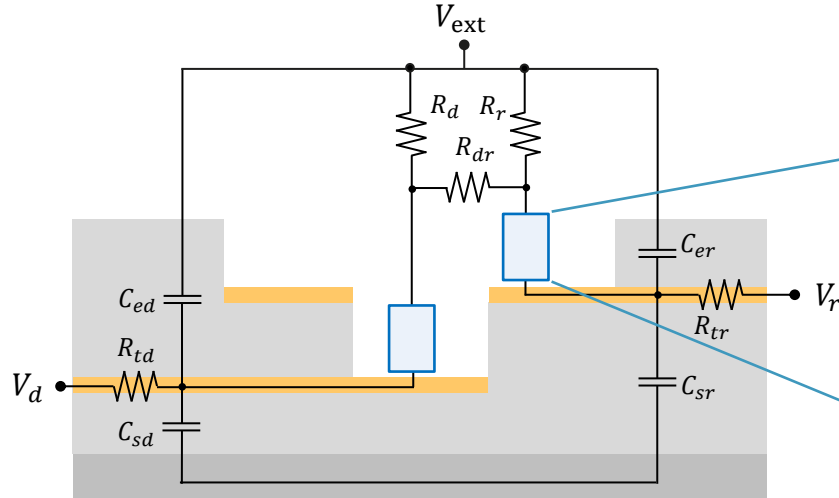


On: 50 μ s
Off: 5 ms

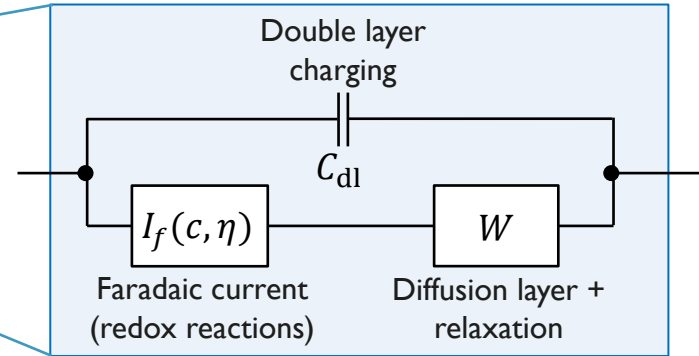


A compact model including electrical and electrochemical circuits enables semi-quantitative non-steady-state analysis

Full circuit for a single synthesis site



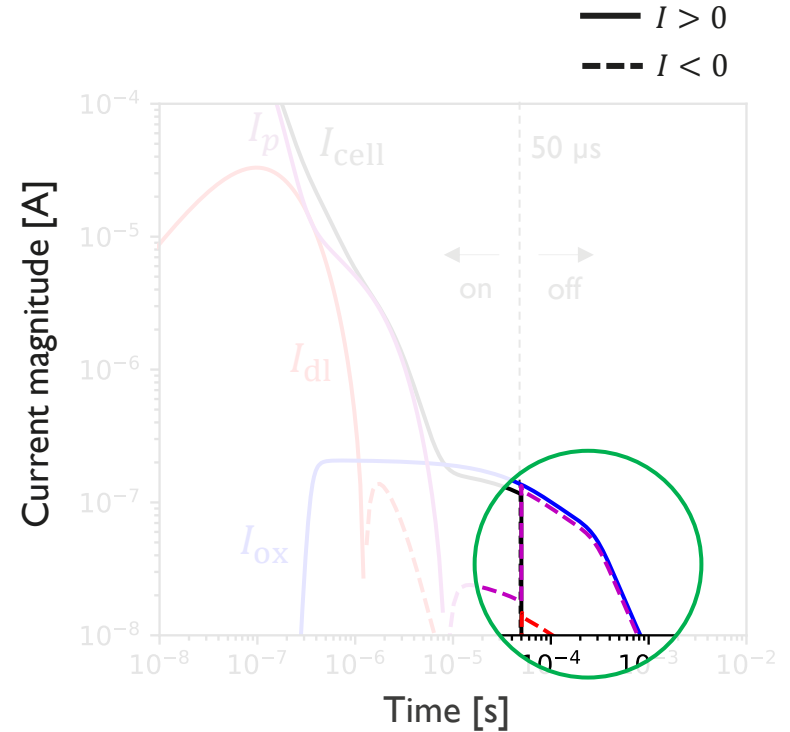
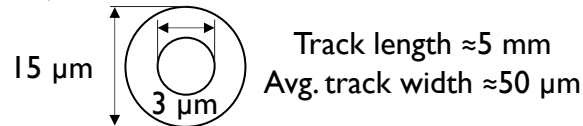
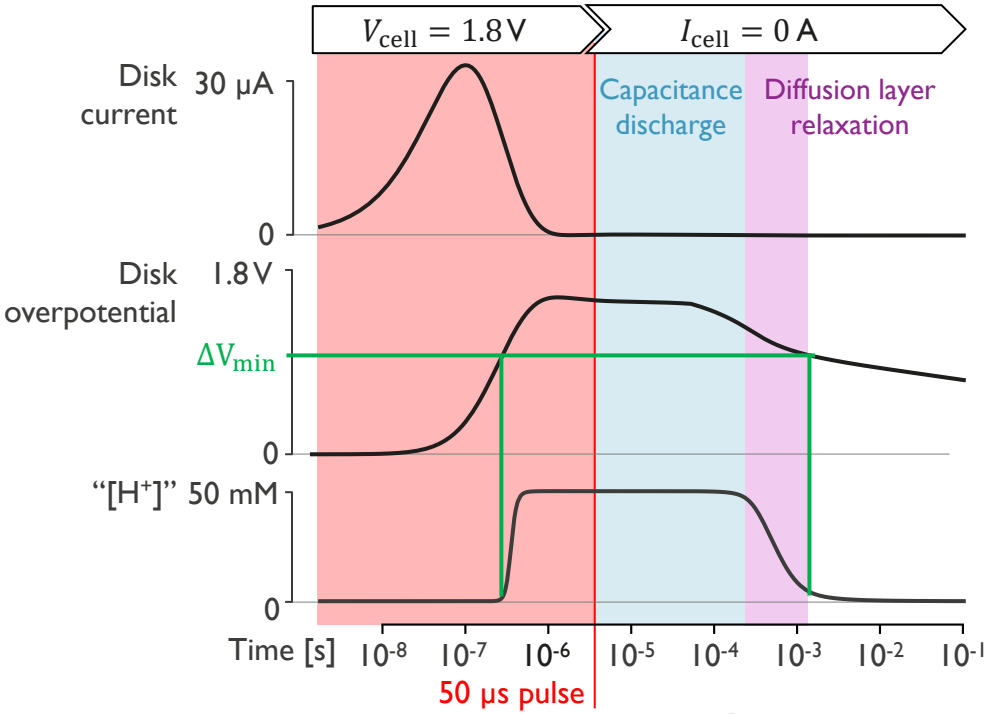
Implementation of an electrode interface



- Electrochemical cell
→ Model ring-disk electrode pair and electrolyte
- Device tracks
→ Include impact of parasitic impedance

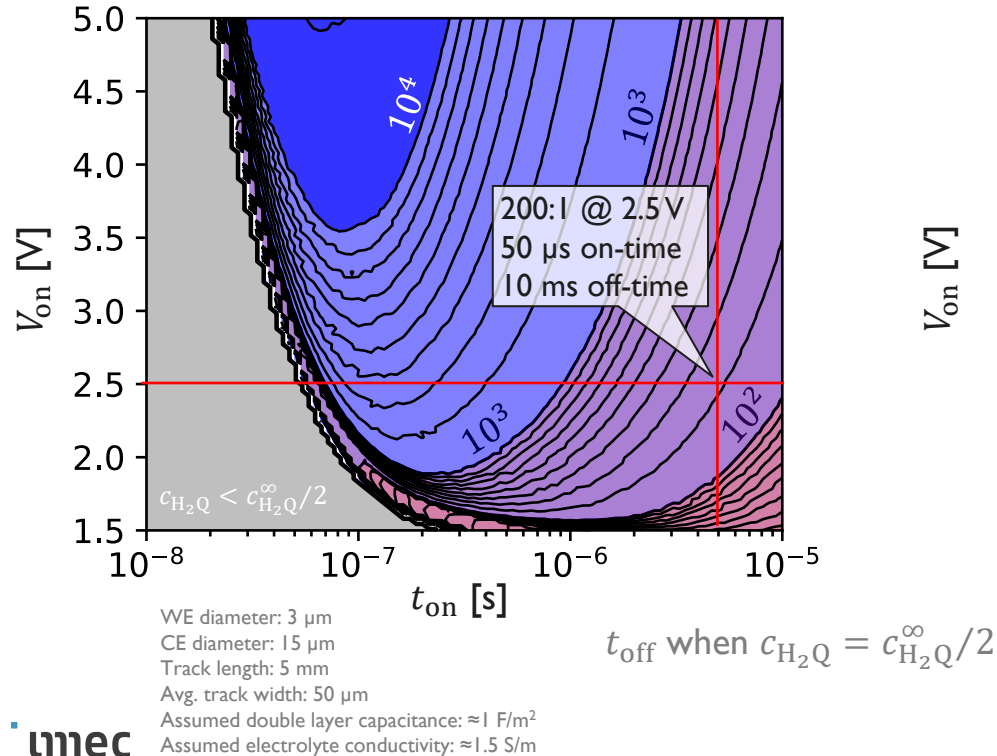
- Faradaic current
→ Reaction kinetics quinone/hydroquinone
- Diffusion layer + relaxation
→ Mass transfer of active species

In our test device, the **electrochemical current** is mainly sustained by **parasitic capacitance of the tracks**

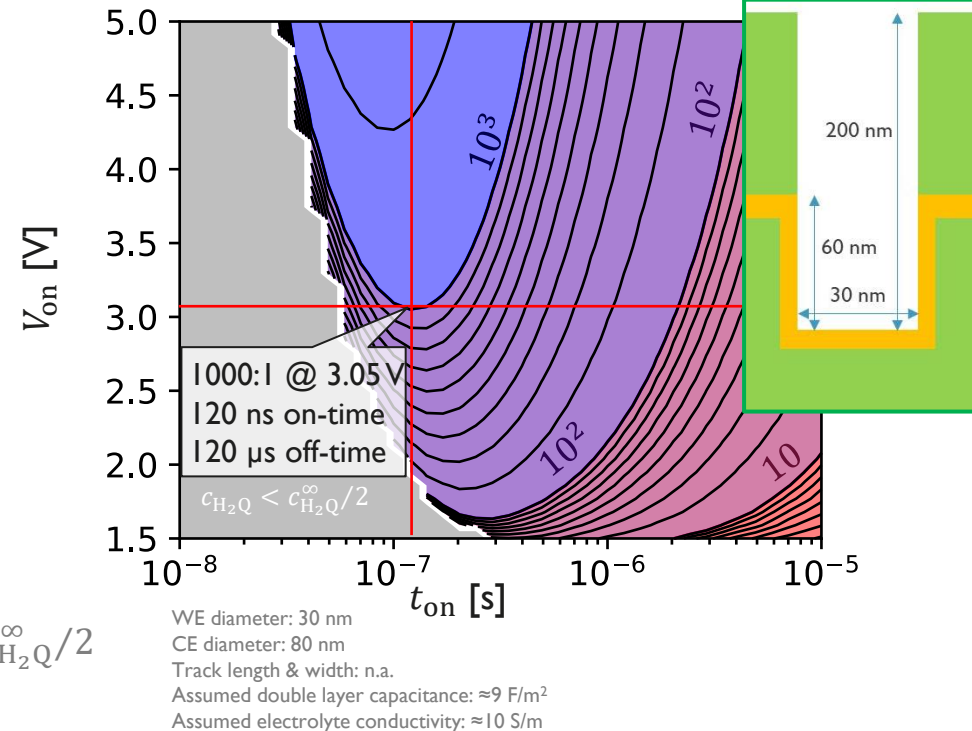


If the **EDL capacitance** and **electrolyte conductivity** are **high**,
scaled devices (~100 nm pitch) can reach **1:1000** on:off ratios

Experimental test electrodes (WE: Ø3 µm)



Scaled electrodes (WE: Ø30 nm)



Conclusions and outlook

- To **further scale** the electrochemical synthesis cell, one must **transition** from **static** (“SRAM”-like) to **dynamic** (“DRAM”-like) **addressing** architectures
- **Simulations** and **experiments** indicate that **dynamic addressing** can maintain a **consistently high proton** concentration for effective **deblocking**
- **Experimentally** observed **time-scales agree with simulations** for passive microelectrode array
- To develop the concept, **further electrode scaling** to **relevant device length-scales** and **CMOS integration** is needed

Acknowledgements

- The SC-DNA 2025 organizers
- My co-authors @ imec
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 - Jelle Fondu
 - Liesbet Lagae
 - Paru Deshpande
 - Rabea Hanifa
 - Wiebe Vanhove



mec

embracing a better life

Diffusion layer relaxation model

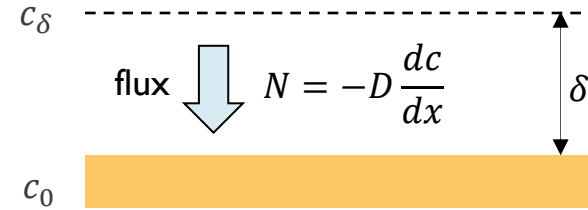
Finite thickness Warburg element
in **frequency domain**

$$\hat{N}(\omega) = H(\omega) \Delta c(\omega)$$

Add correct
equation

Finite thickness Warburg element
in **time domain**

$$N(t) = \frac{D}{\delta} (c_\delta - c_0) - \frac{2D}{\ell} \int_0^t \sum_{n=1}^{\infty} e^{-\frac{n^2 \pi^2 D (t-\tau)}{\delta^2}} \frac{dc_0}{d\tau} d\tau$$



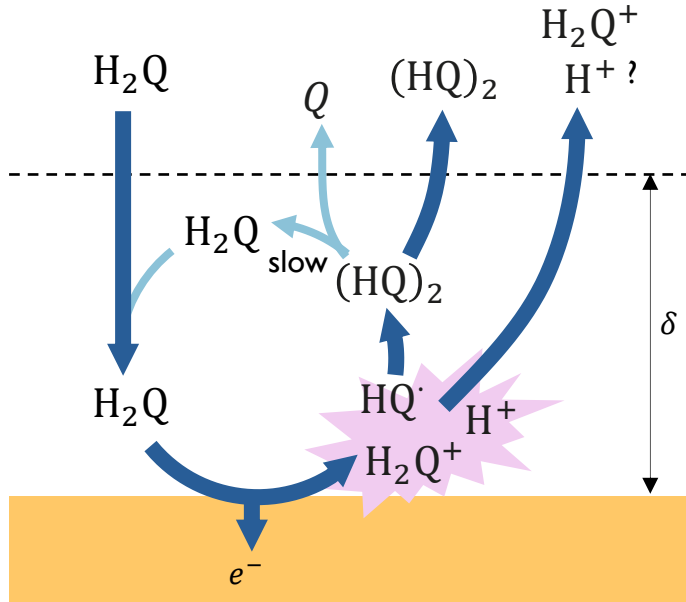
Practical **compact model**
(first order approximation)

$$\frac{3\delta}{\pi^2} \frac{dc_0}{dt} = -\frac{D}{\delta} (c_\delta - c_0) + \left(\cancel{N(t)} + \frac{\delta^2}{\pi^2 D} \frac{dN}{dt} \right)$$

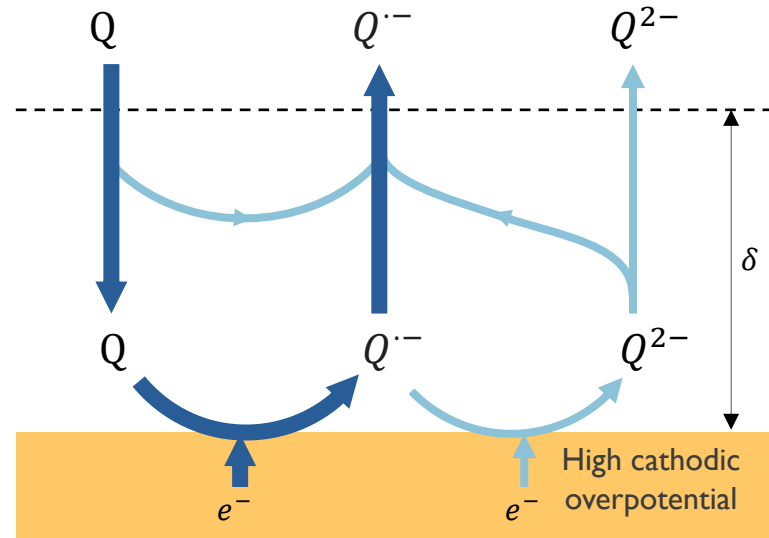
The flux N follows from the kinetics
of the electrochemical reactions

Faradaic reactions

Hydroquinone



Benzoquinone



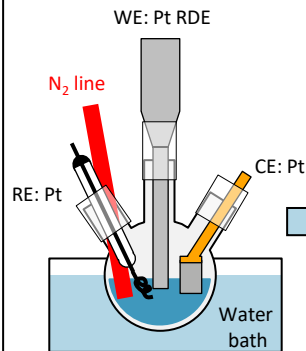
Parameter estimation through literature & independent experiments

Components

Hydroquinone
Benzoquinone
50 mM TBAPF

Dissolved in

10 vol% MeOH
90 vol% Acetonitrile



$$\begin{aligned} \frac{\partial c_{H_2Q}}{\partial t} &= D_{H_2Q} \frac{\partial^2 c_{H_2Q}}{\partial x^2} - \frac{\alpha \Omega^{3/2} x^2}{\nu^{1/2}} \frac{\partial c_{H_2Q}}{\partial x} + R_2 & -D_{H_2Q} \frac{\partial c_{H_2Q}}{\partial x} \Big|_0 &= -S_1 \\ \frac{\partial c_{H_2Q^+}}{\partial t} &= D_{H_2Q^+} \frac{\partial^2 c_{H_2Q^+}}{\partial x^2} - \frac{\alpha \Omega^{3/2} x^2}{\nu^{1/2}} \frac{\partial c_{H_2Q^+}}{\partial x} - 2R_1 & -D_{H_2Q^+} \frac{\partial c_{H_2Q^+}}{\partial x} \Big|_0 &= S_1 \\ \frac{\partial c_Q}{\partial t} &= D_Q \frac{\partial^2 c_Q}{\partial x^2} - \frac{\alpha \Omega^{3/2} x^2}{\nu^{1/2}} \frac{\partial c_Q}{\partial x} + R_2 & -D_Q \frac{\partial c_Q}{\partial x} \Big|_0 &= -S_2 - S_3 \\ \frac{\partial c_{H^+}}{\partial t} &= D_{H^+} \frac{\partial^2 c_{H^+}}{\partial x^2} - \frac{\alpha \Omega^{3/2} x^2}{\nu^{1/2}} \frac{\partial c_{H^+}}{\partial x} + 2R_1 & -D_{H^+} \frac{\partial c_{H^+}}{\partial x} \Big|_0 &= -S_2 \\ \frac{\partial c_{(HQ)_2}}{\partial t} &= D_{(HQ)_2} \frac{\partial^2 c_{(HQ)_2}}{\partial x^2} - \frac{\alpha \Omega^{3/2} x^2}{\nu^{1/2}} \frac{\partial c_{(HQ)_2}}{\partial x} + R_1 - R_2 & -D_{(HQ)_2} \frac{\partial c_{(HQ)_2}}{\partial x} \Big|_0 &= \frac{S_2}{2} \\ \frac{\partial c_{Q^-}}{\partial t} &= D_{Q^-} \frac{\partial^2 c_{Q^-}}{\partial x^2} - \frac{\alpha \Omega^{3/2} x^2}{\nu^{1/2}} \frac{\partial c_{Q^-}}{\partial x} & -D_{Q^-} \frac{\partial c_{Q^-}}{\partial x} \Big|_0 &= S_3 \end{aligned}$$

$$\begin{aligned} H_2Q &\rightarrow H_2Q^+ + e^- & S_1 &= k_{ox} c_{H_2Q} \exp\left(\frac{\alpha_1 F \eta}{RT}\right) \\ Q + H^+ + e^- &\rightarrow (HQ)_2/2 & S_2 &= k_{red} c_Q c_{H^+} \exp\left(-\frac{\alpha_2 F \eta}{RT}\right) \\ Q + e^- &\rightleftharpoons Q^- & S_3 &= k_0 \left\{ c_Q \exp\left(-\frac{\alpha_3 F [\eta - E_0]}{RT}\right) - c_{Q^-} \exp\left(\frac{\alpha_3 F [\eta - E_0]}{RT}\right) \right\} \\ 2H_2Q^+ &\rightarrow (HQ)_2 + 2H^+ & R_1 &= k_1 c_{H_2Q^+}^2 \\ (HQ)_2 &\rightarrow Q + H_2Q & R_2 &= k_2 c_{(HQ)_2} \end{aligned}$$

Parameters

$$D_{H_2Q} = 2.8 \times 10^{-9} \text{ m}^2/\text{s}$$

$$D_{H_2Q^+} = D_{H_2Q}$$

$$D_Q = 3.2 \times 10^{-9} \text{ m}^2/\text{s}$$

$$D_{Q^-} = D_Q$$

$$D_{H^+} =$$

$$D_{(HQ)_2} = 1 \times 10^{-9} - 2 \times 10^{-9} \text{ m}^2/\text{s}$$

$$k_{ox} = 8 \times 10^{-13} \text{ m/s}$$

$$k_{red} = 4 \times 10^{-3} \text{ m/s}$$

$$k_1 > 1500 \text{ m}^3/\text{mol} \cdot \text{s}$$

$$k_2 > 1000 \text{ s}^{-1}$$

$$E_0 = -0.45 \text{ V}$$

$$\alpha_1 = \alpha_2 = \alpha_3 = 0.5$$

Proton Effects in the Electrochemistry of the Quinone Hydroquinone System in Aprotic Solvents

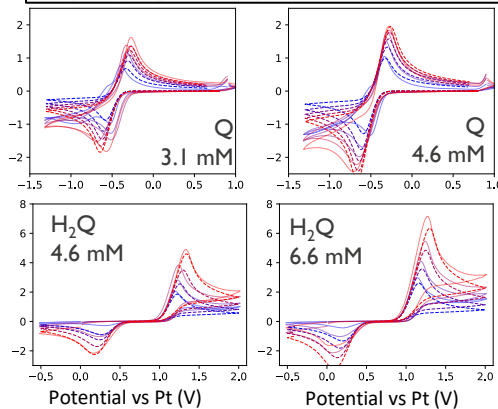
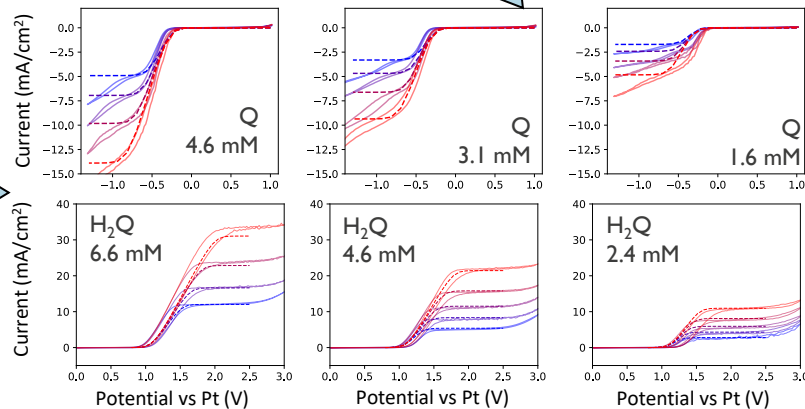
B. R. Eggins and J. Q. Chambers†
Department of Chemistry, University of Colorado, Boulder, Colorado

J. Electrochem. Soc. (1970)

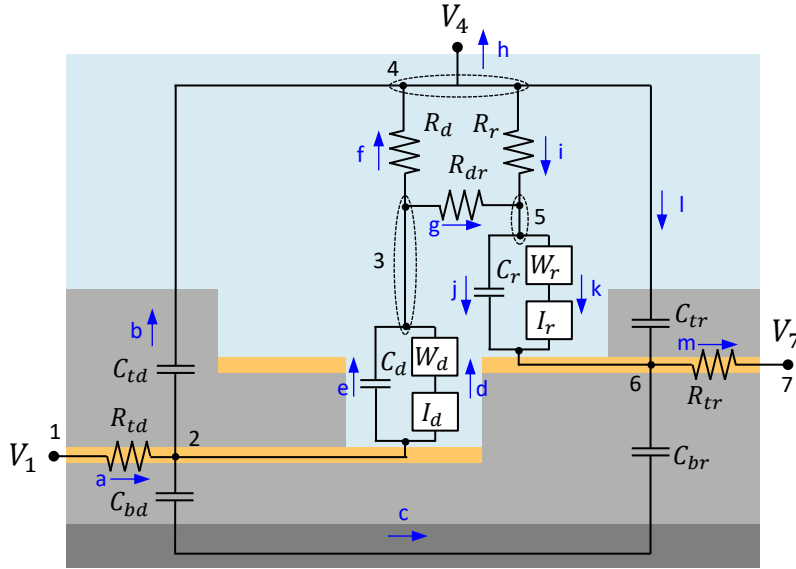
Acid/base and hydrogen bonding effects on the proton-coupled electron transfer of quinones and hydroquinones in acetonitrile: Mechanistic investigation by voltammetry, ¹H NMR and computation

Timothy M. Alligant^a, John C. Hackett^b, Julio C. Alvarez^{a,*}

E. Acta (2010)



Simplified model for microelectrode simulation



Node 2 $0 = I_a - I_b - I_c - I_d - I_e$

Node 3 $0 = I_d + I_e - I_f - I_g$

Node 4 $0 = I_b + I_f - I_i - I_l$

Node 5 $0 = I_g + I_i - I_j - I_k$

Node 6 $0 = I_j - I_k + I_l + I_c - I_m$

Track R $0 = V_1 - V_2 - R_{td}I_a$

Track C $0 = C_{td}(\dot{V}_2 - \dot{V}_4) - I_b$

Track C $0 = (C_{bd}^{-1} + C_{br}^{-1})^{-1}(\dot{V}_2 - \dot{V}_6) - I_c$

HQ ox $0 = I_d - A_d F k_d c_{H_2Q} \exp\left(\frac{\alpha_{ox} F}{RT}(V_2 - V_3)\right)$

Disk C $0 = C_d(\dot{V}_2 - \dot{V}_3) - I_e$

Warburg $0 = \frac{3\ell_d}{\pi^2} \dot{c}_{H_2Q} - \frac{D_{H_2Q}}{\ell_d} (c_{H_2Q}^\infty - c_{H_2Q}) + \frac{1}{n_e F A_d} \left(I_d + \frac{\ell_d^2}{\pi^2 D_{H_2Q}} \dot{I}_d \right)$

Disk R $0 = V_3 - V_4 - R_d I_f$

Liquid R $0 = V_3 - V_5 - R_{dr} I_f$

Q red $0 = I_k - A_r k_r F \left[\begin{array}{l} c_Q \exp\left(\frac{\alpha_{red} F}{RT}(V_5 - V_6 + E_0)\right) \\ -(c_Q^\infty - c_Q) \exp\left(-\frac{(1-\alpha_{red}) F}{RT}(V_5 - V_6 + E_0)\right) \end{array} \right]$

Ring C $0 = C_r(\dot{V}_5 - \dot{V}_6) - I_j$

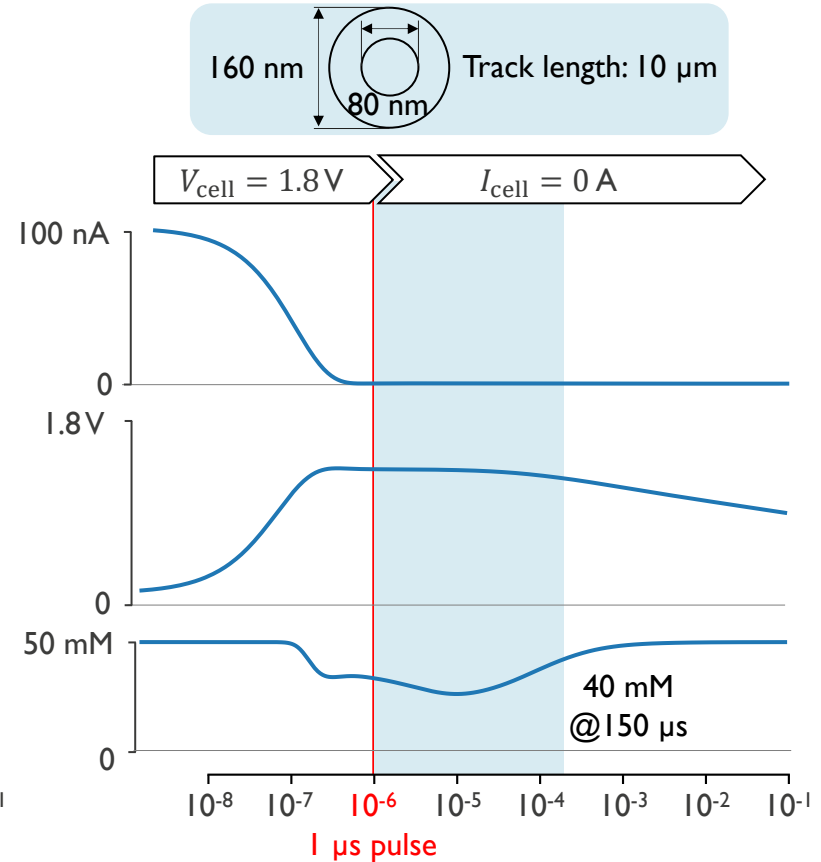
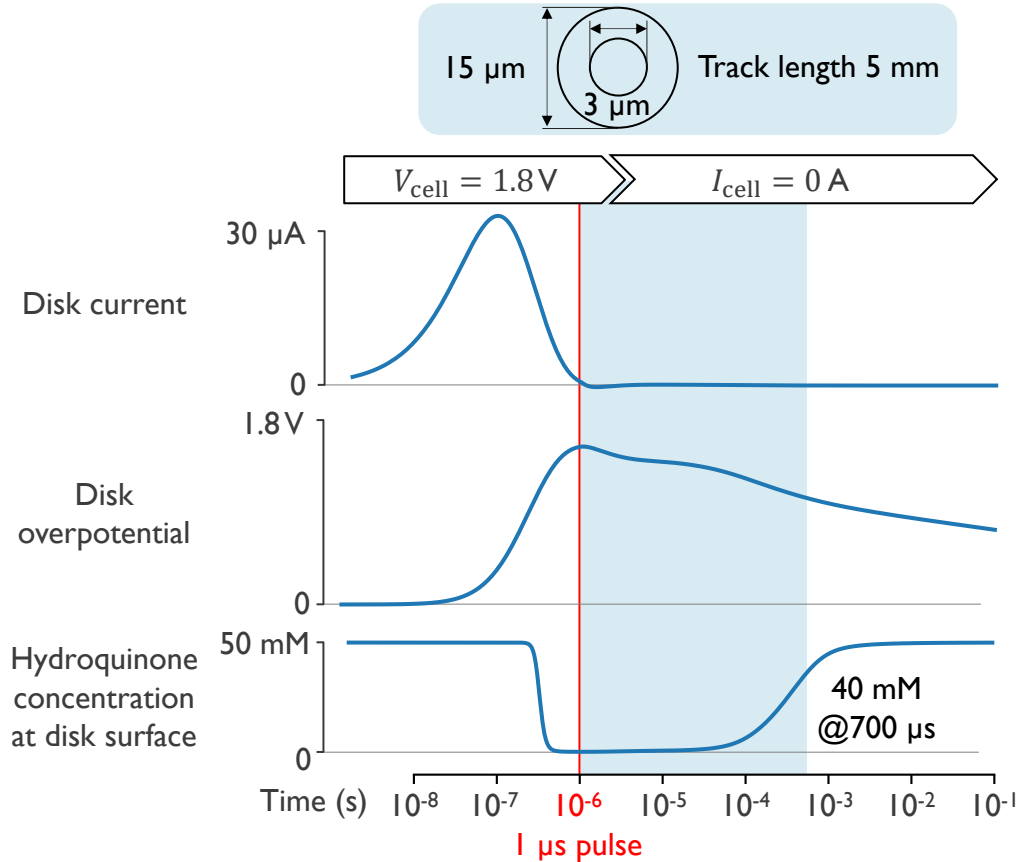
Warburg $0 = \frac{3\ell_r}{\pi^2} \dot{c}_Q - \frac{D_Q}{\ell_r} (c_Q^\infty - c_Q) + \frac{1}{n_e F A_r} \left(I_r + \frac{\ell_r^2}{\pi^2 D_Q} \dot{I}_r \right)$

Ring R $0 = (V_4 - V_5) - R_r I_i$

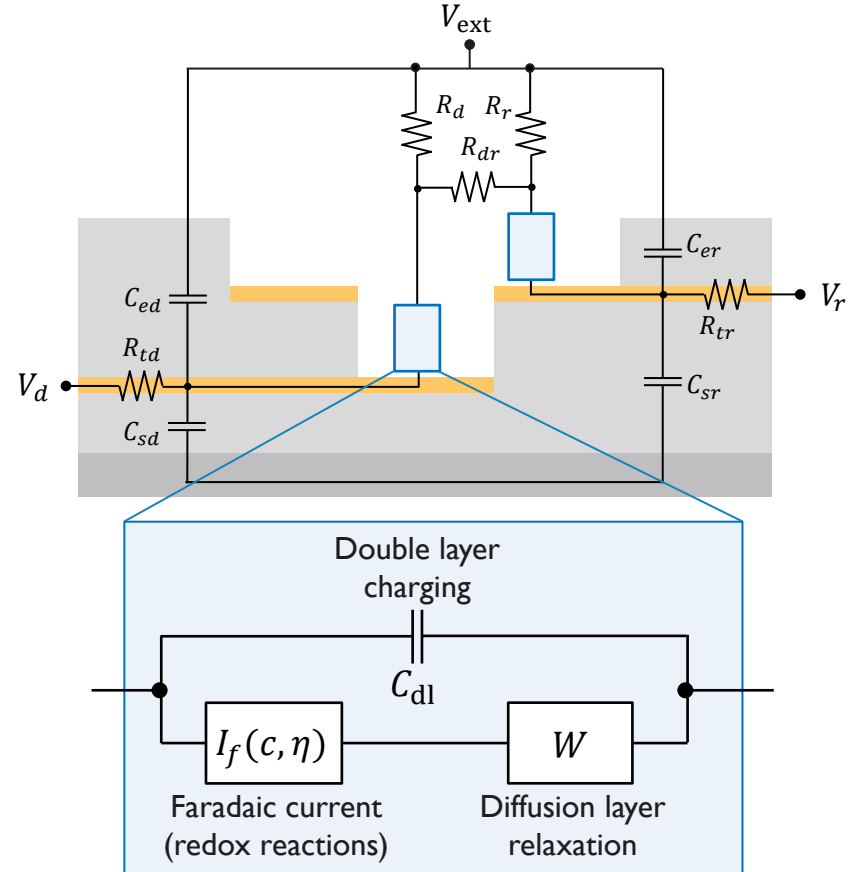
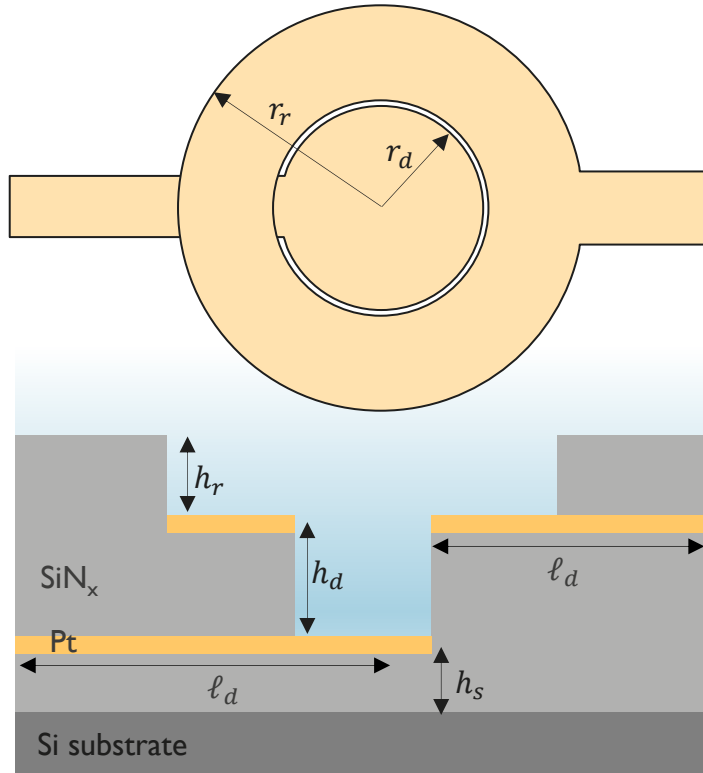
Track C $0 = C_{tr}(\dot{V}_4 - \dot{V}_6) - I_l$

Track R $0 = V_6 - V_7 - R_{tr} I_m$

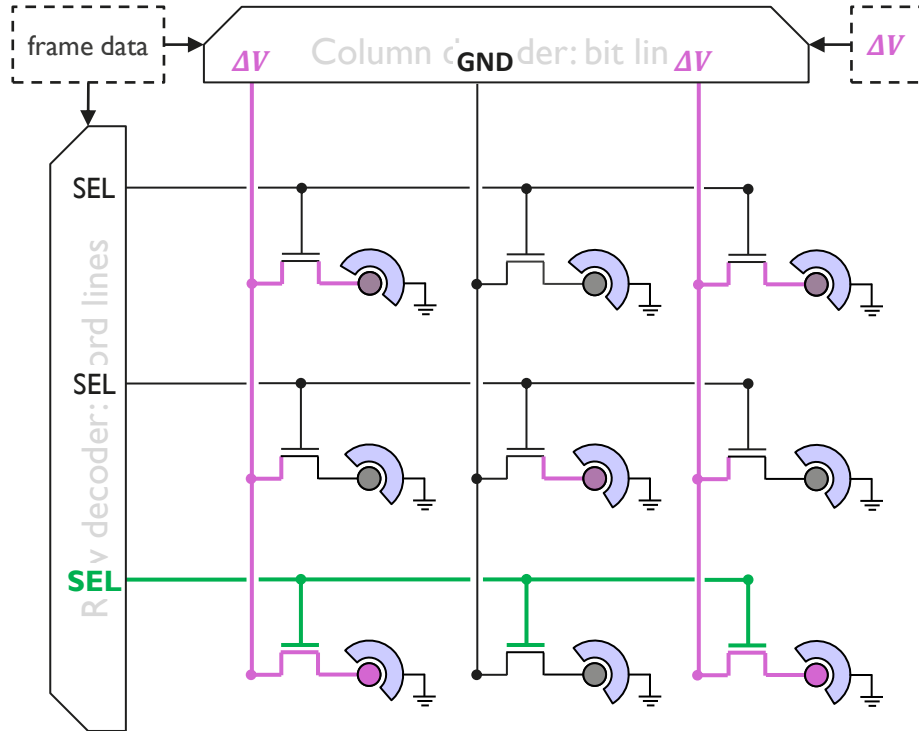
Typical response for experimental device



Geometry and corresponding compact circuit model

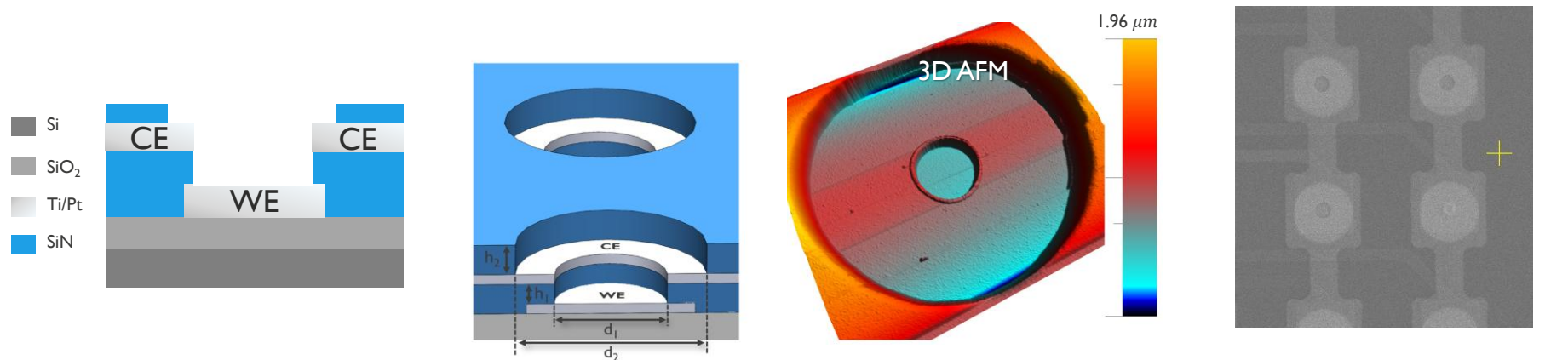


Harnessing DRAM concepts for high-density multiplexed electrode array addressing

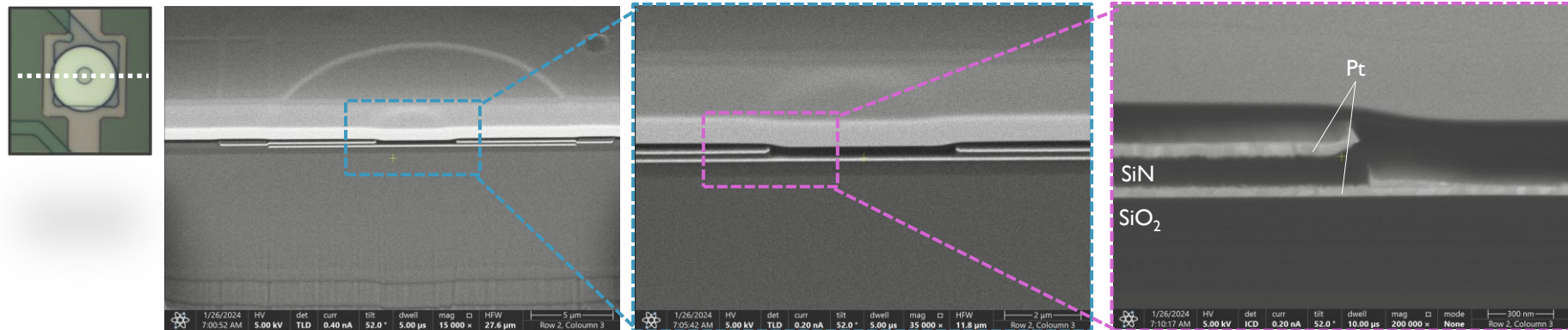


- Electrode activation pattern ("frame") is loaded in separate memory array and send to synthesis array row-by-row
 - Row decoder sequentially activates each wordline, which turn on the access transistors
 - Synchronously, the column decoder sets the bitlines to either the driving voltage ("ON") or ground ("OFF")
 - Transient activation results in the charging of the cell capacitance
 - the resulting voltage difference then drives the electrochemical reaction, whose potential
- The transient charging of the capacitance of the cell allows for an electrochemical current
- This pattern is repeated until the electrochemical

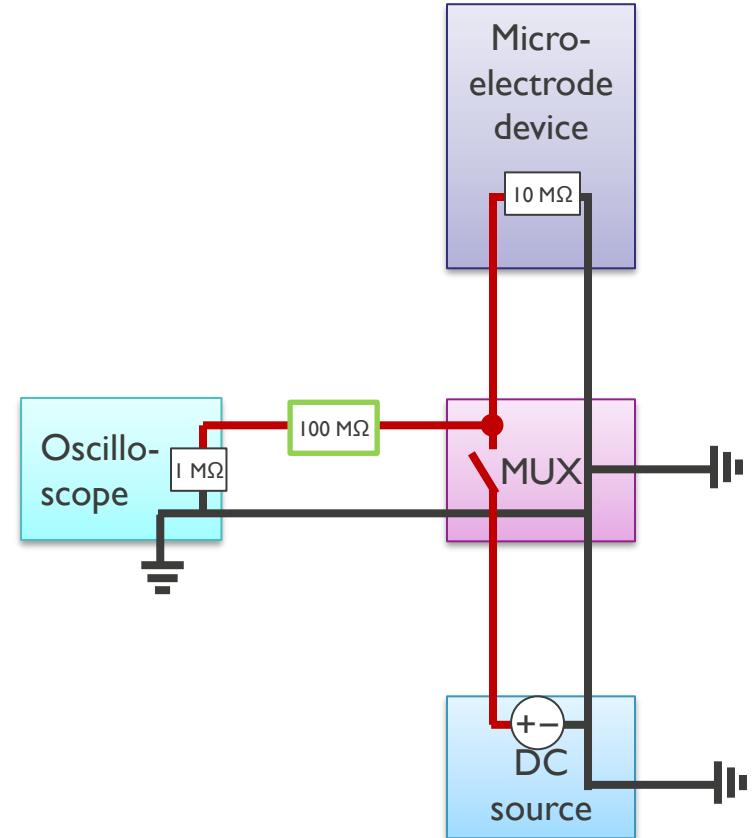
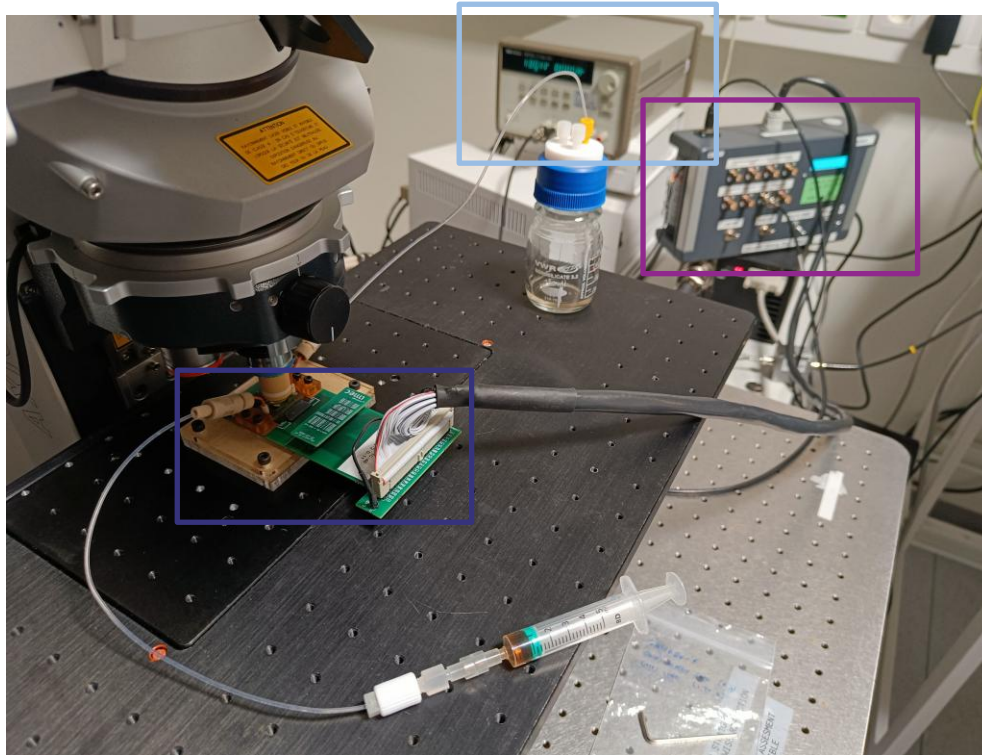
Device topography (AFM) and x-section (FIB-SEM) characterization



FIB-SEM



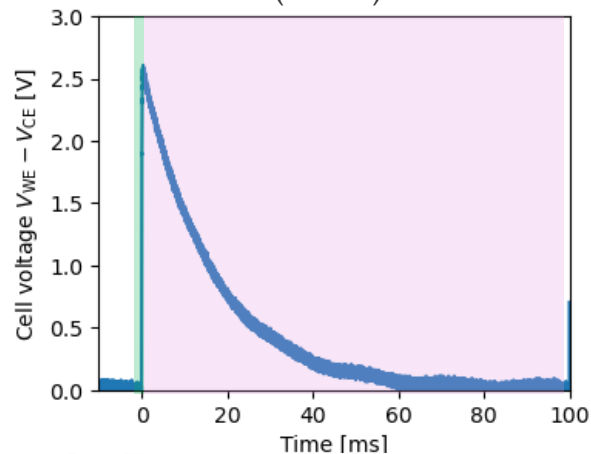
Setup allows for simultaneous electrical and optical measurements



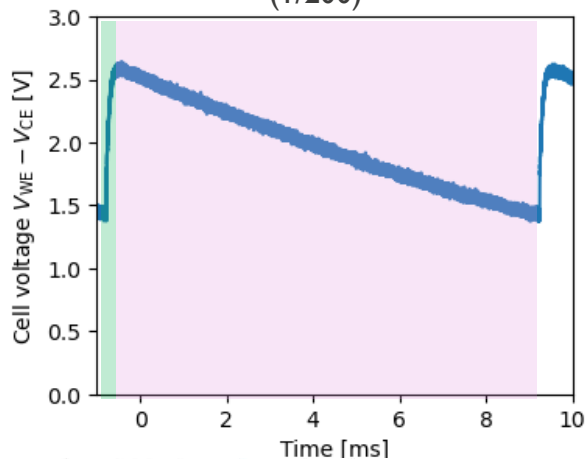
Impact of “off time” on the cell voltage

HQ/BQ 50/10 mM
10 mM lut
50 mM TEAPS
90:10 v/v% ACN/MeOH

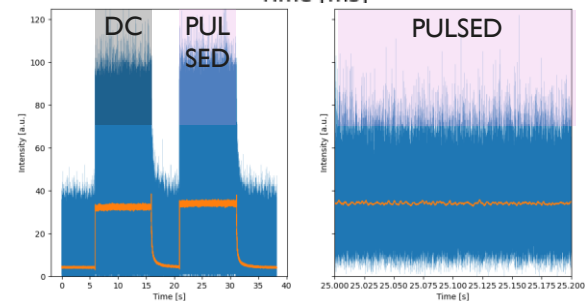
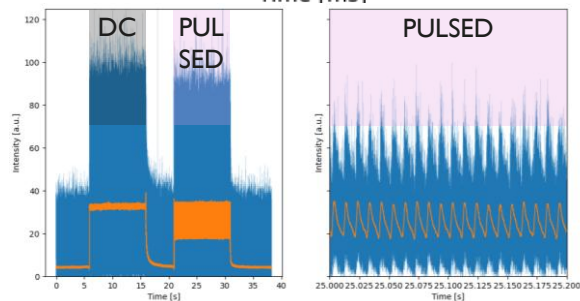
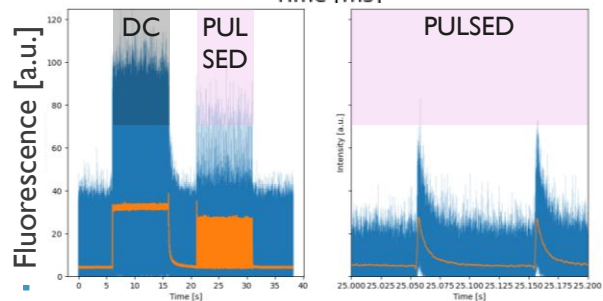
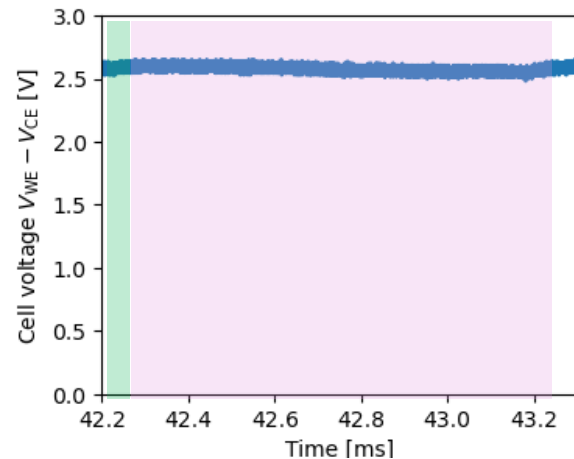
50 μ s on @ 2.5V + 100 ms off @ OCP
(1/2000)



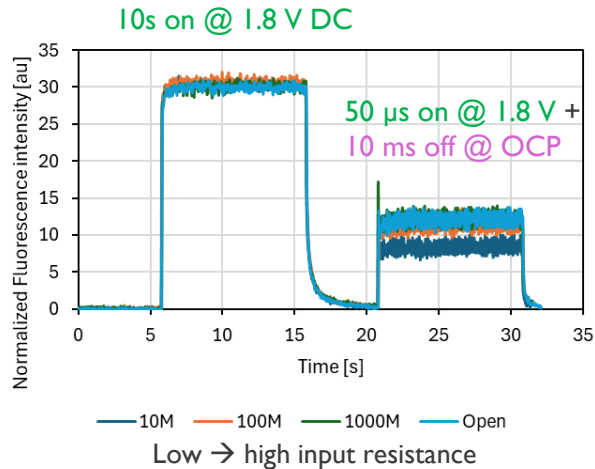
50 μ s on @ 2.5V + 10 ms off @ OCP
(1/200)



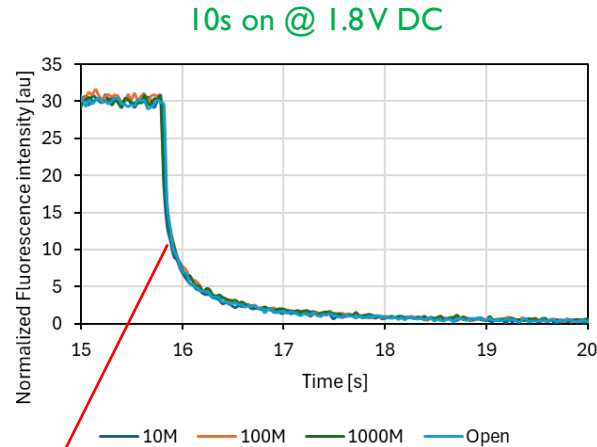
50 μ s on @ 2.5V + 1 ms off @ OCP
(1/20)



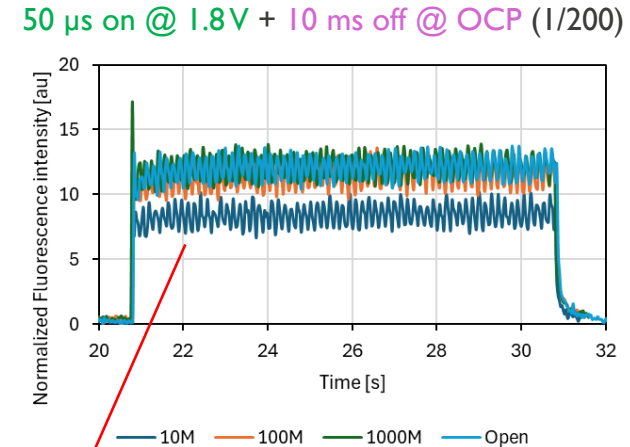
Impact of oscilloscope connection on the fluorescence intensity



HQ/BQ 50/10 mM
10 mM lutidine
50 mM TEAPS
90:10 v/v% ACN/MeOH

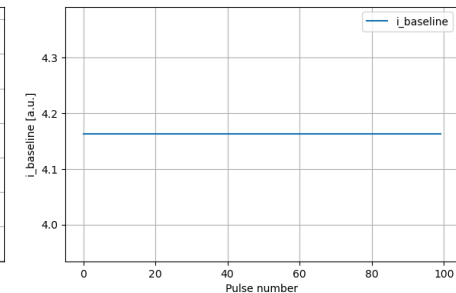
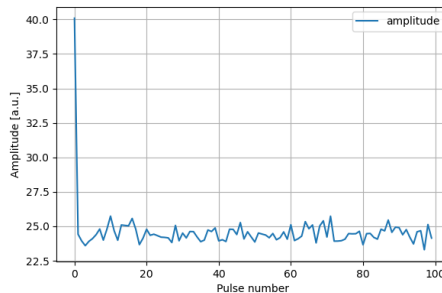
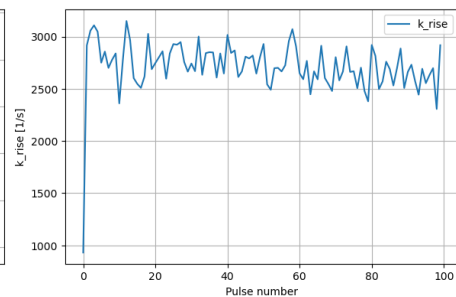
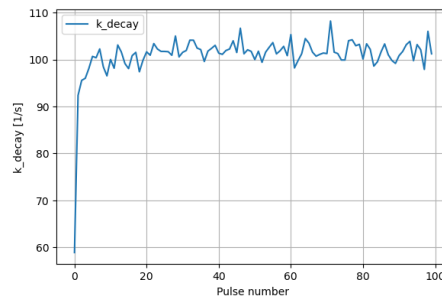
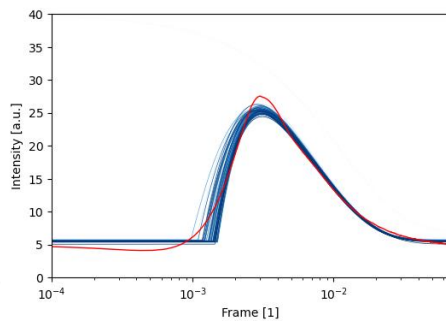
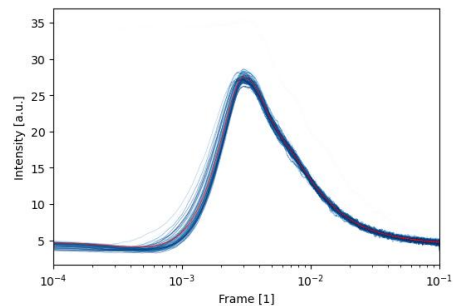
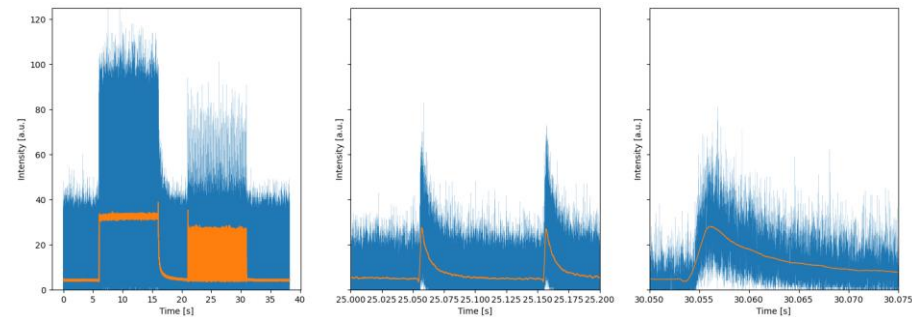


No clear impact of oscilloscope connection and input resistance on decay in fluorescence intensity



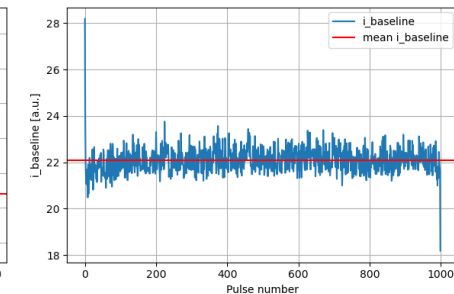
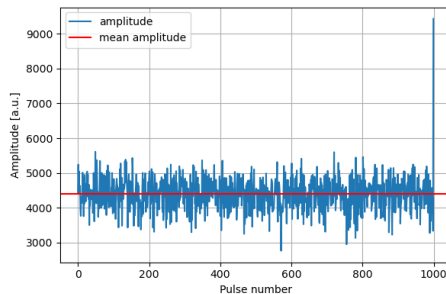
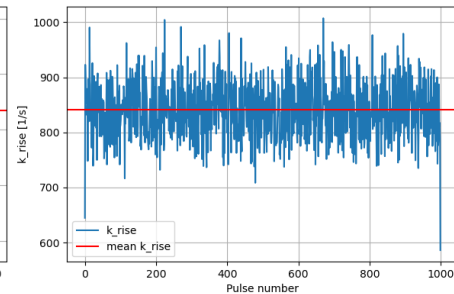
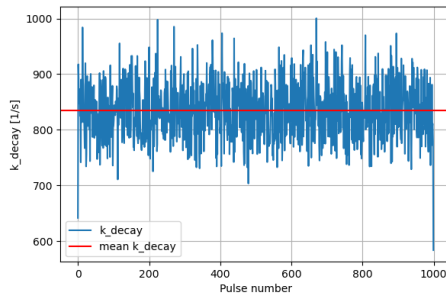
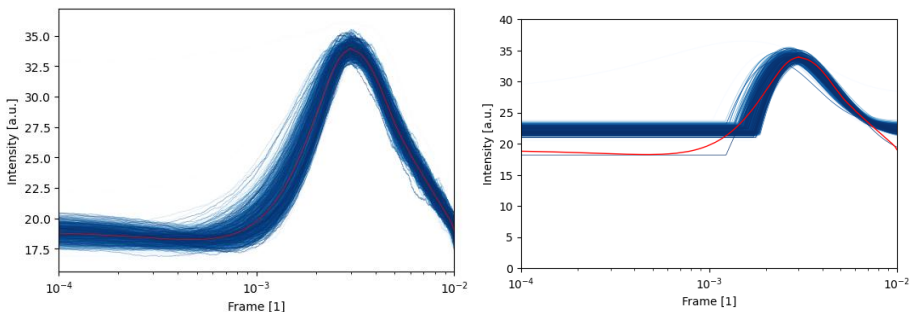
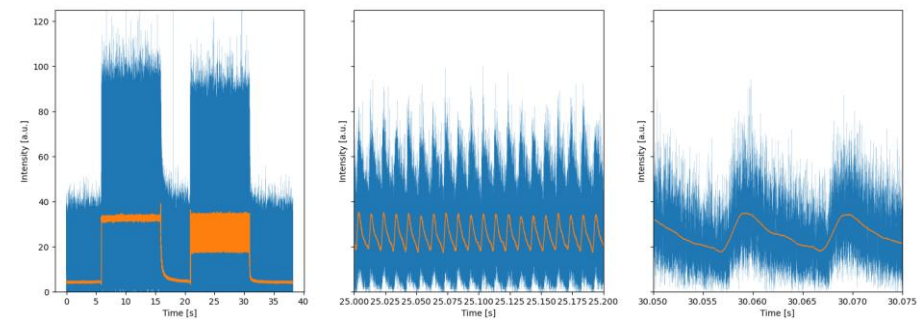
During pulsing: Steady-state fluorescence intensity reduced when using low input resistance

20240613_pulsing_V1.8_0103M Ohm_on000050_off100000_spot.czi



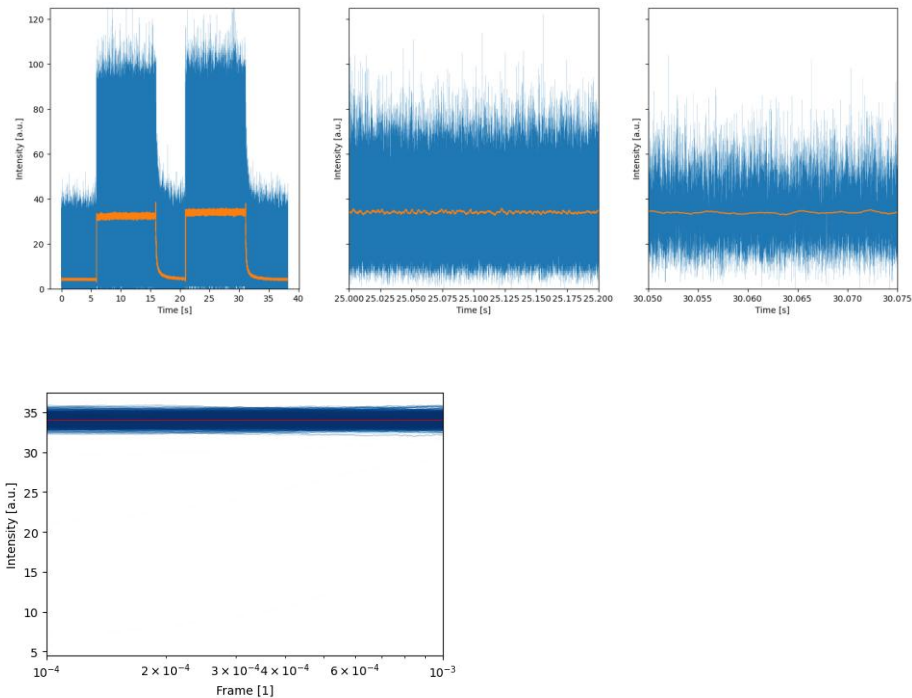
Mean k_{decay} : 100.93 1/s
Mean k_{rise} : 2712.23 1/s
Mean amplitude: 24.58 a.u.
Mean i_{baseline} : 4.16 a.u.

20240613_pulsing_V1.8_0103M0hm_on000050_off010000_spot.czi



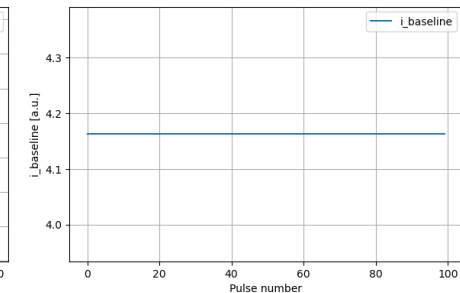
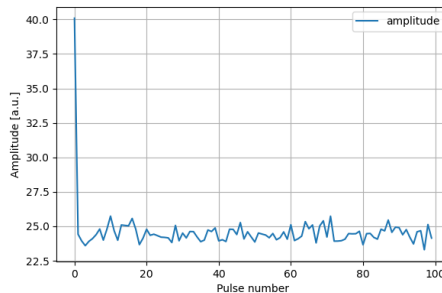
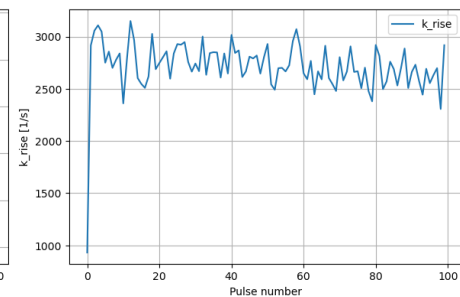
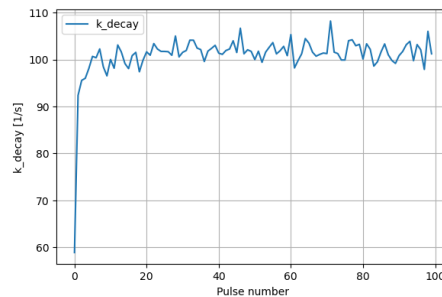
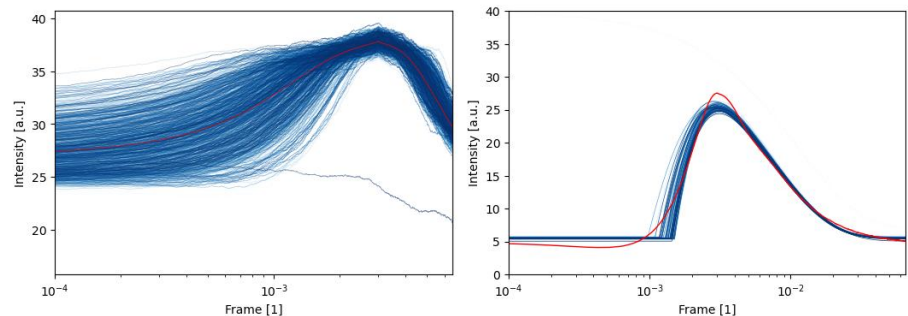
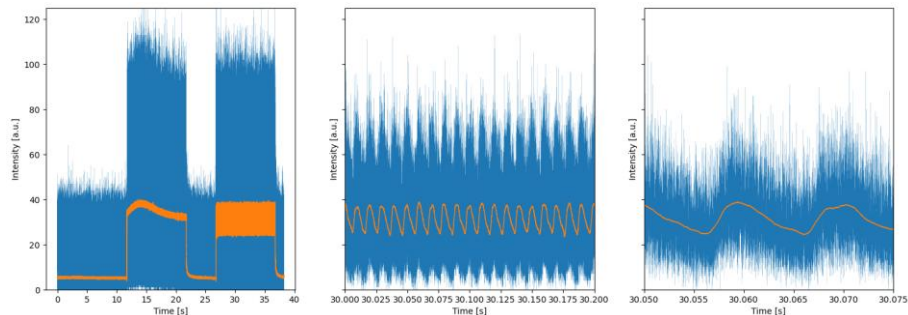
Mean k_{decay} : 835.04 1/s
Mean k_{rise} : 841.25 1/s
Mean amplitude: 4396.34 a.u.
Mean i_{baseline} : 22.09 a.u.

20240613_pulsing_V1.8_0103M0hm_on000050_off001000_spot.czi



Mean baseline: 34.01 a.u.

20240613_pulsing_V2.5_0103M0hm_on000050_off010000_spot.czi



Mean k_{decay} : 100.93 1/s
Mean k_{rise} : 2712.23 1/s
Mean amplitude: 24.58 a.u.
Mean i_{baseline} : 4.16 a.u.